

Transport through Nanostructures

Sibylle Gemming

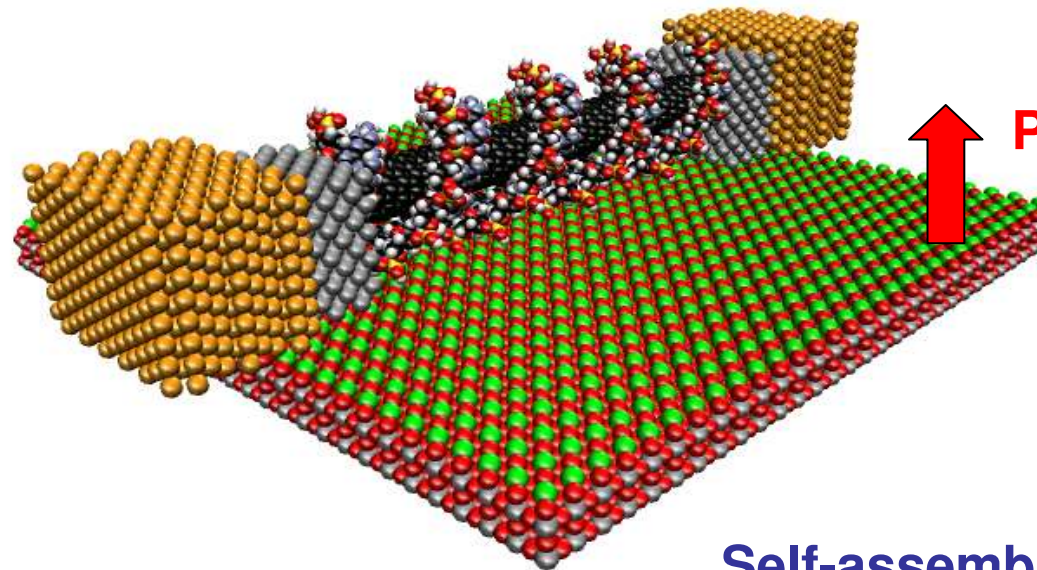
Institut für Ionenstrahlphysik und Materialforschung
Forschungszentrum Dresden-Rossendorf
Pf 510119, D-01314 Dresden



**Forschungszentrum
Dresden** Rossendorf

Organic field-effect transistor on ferroic substrate

FET-prototype



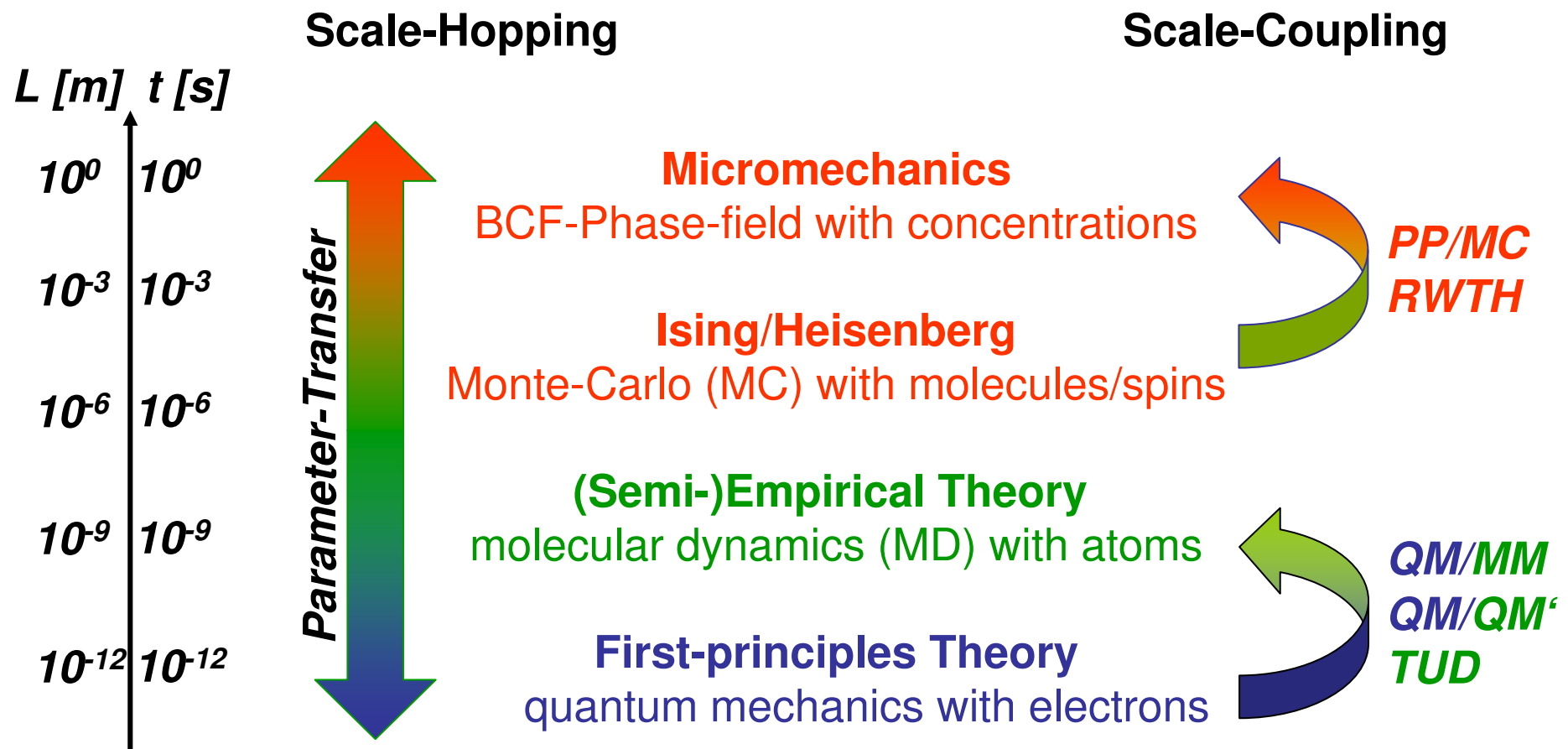
Gate: (7,3)CNT @ polyG-DNA
 Contact: Ti/Au electrodes
 Field: BaTiO₃ surface polarisation

Self-assembled monolayer gate?

Continuous wire/tube gate?

Switching?

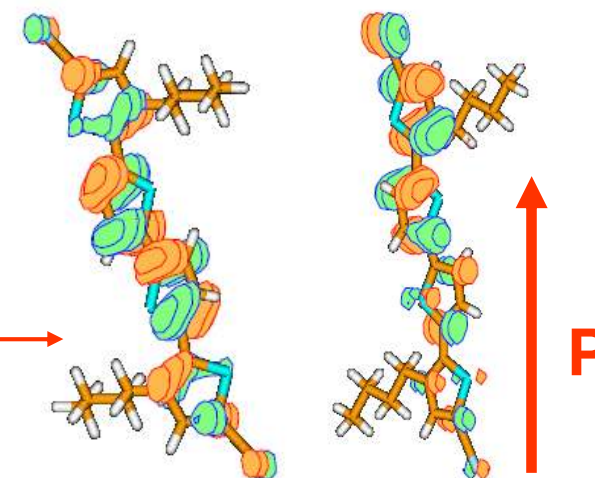
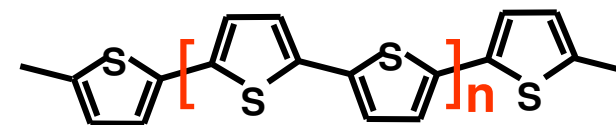
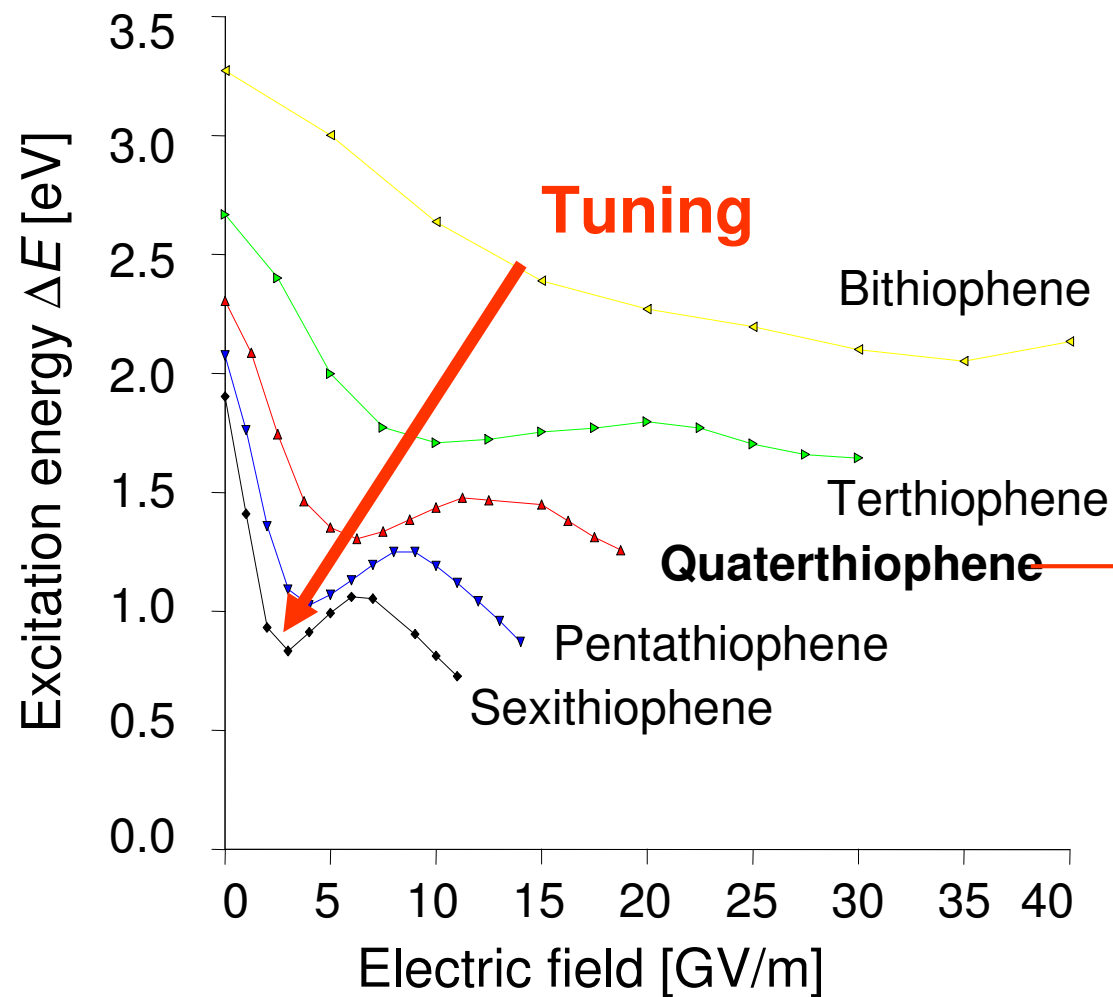
Scale-bridging approaches



Self-assembled monolayer gate

Thiophenes

Field sensitivity of oligothiophenes



J Computer-Aided Mater Des (2007) 14:211–218
 DOI 10.1007/s10820-007-9076-7

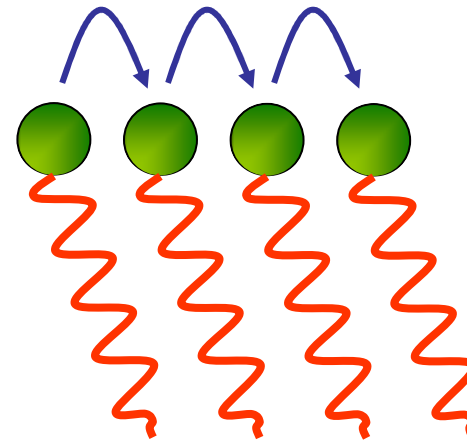
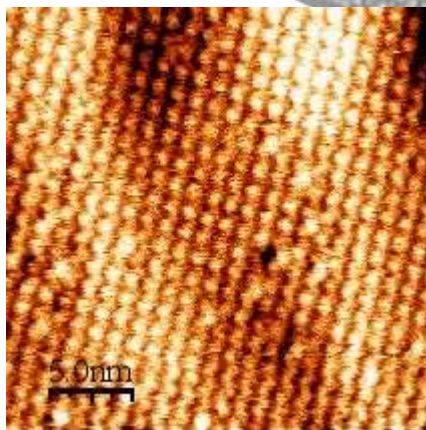
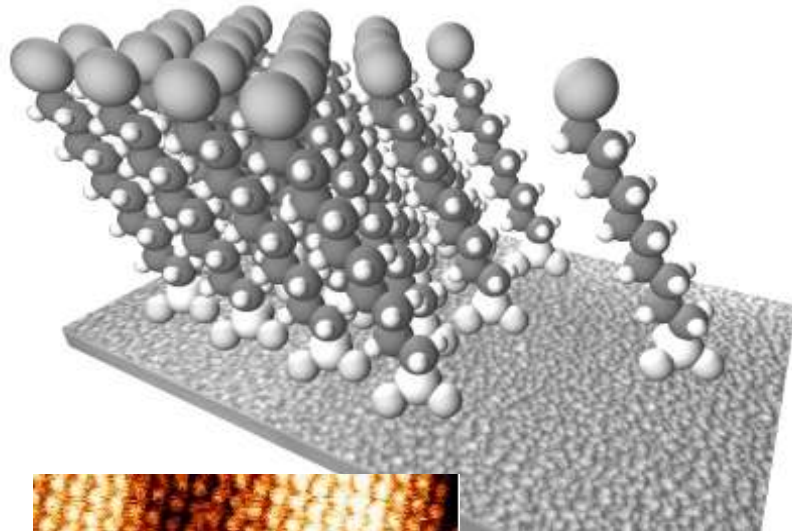
Modelling ferroic functional elements

S. Gemming · R. Lushtinetz · W. Alsheimer

G. Seifert · Ch. Loppacher · L. M. Eng

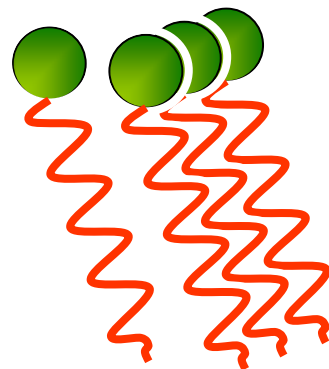
Transport mechanisms

Self-organized QT layer



Hopping

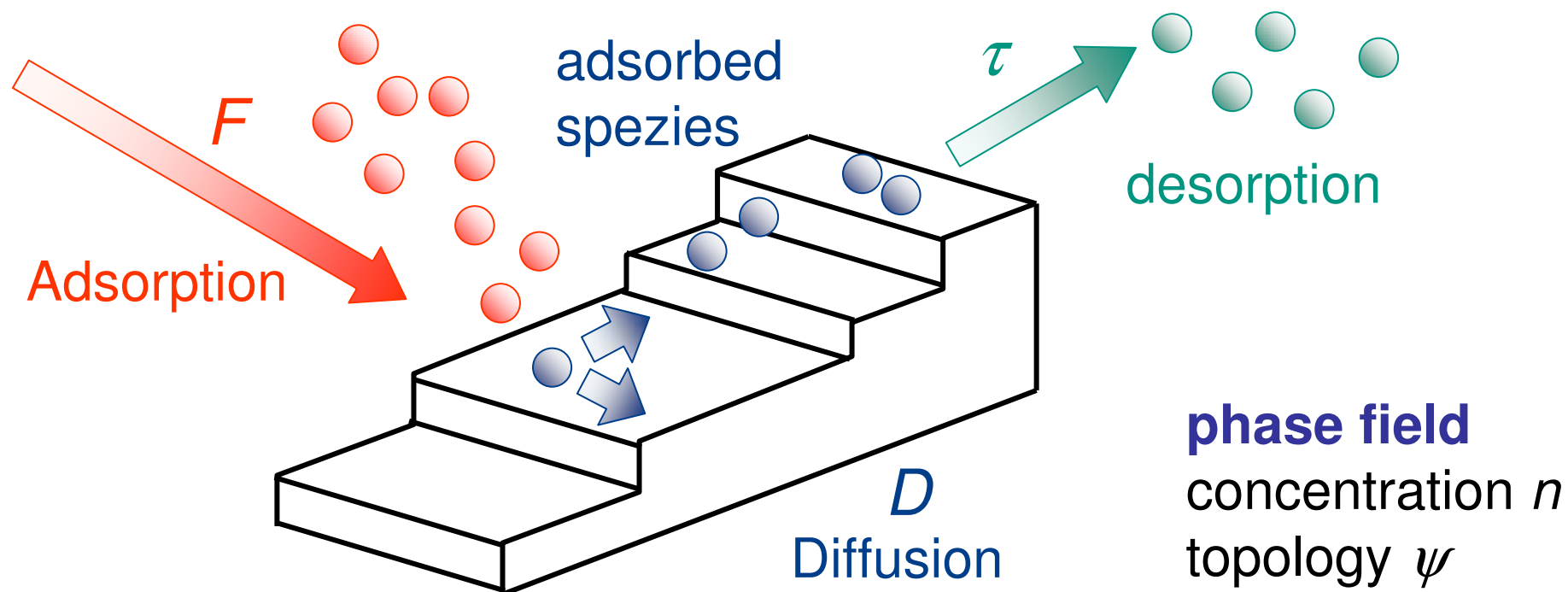
classical
master equation
semi-classical
tight-binding



Shuttling

classical
elasto-mechanics

Self-assembly – Burton-Cabrera-Franck



DFT-HF/MP2

interactions

molecule-molecule
molecule-surface

J, H

**Metropolis-
Monte-Carlo**

$\langle D \rangle, \langle \tau \rangle, \langle n \rangle$

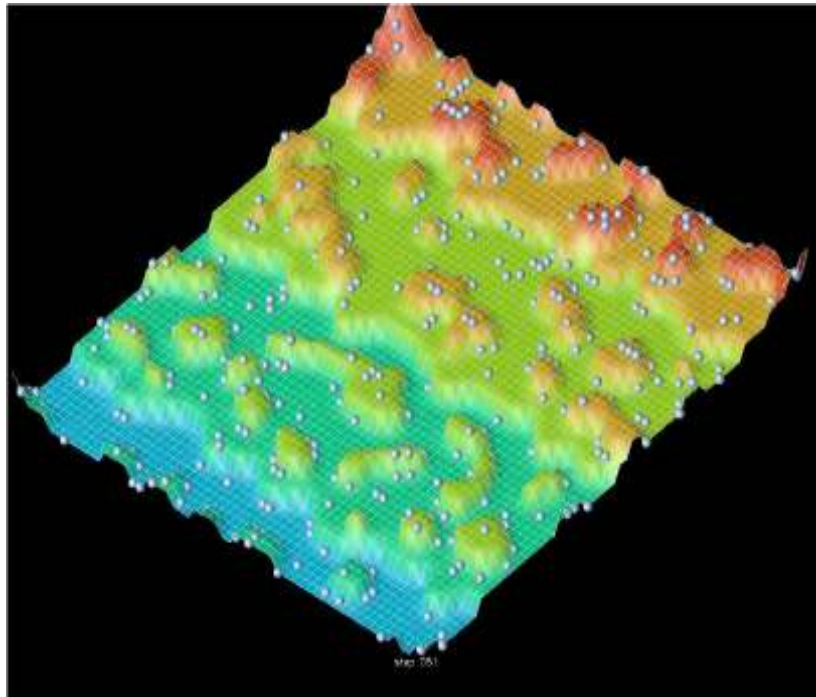
phase field

concentration n

topology ψ

Growth modes on structured surfaces

Island – layer-growth



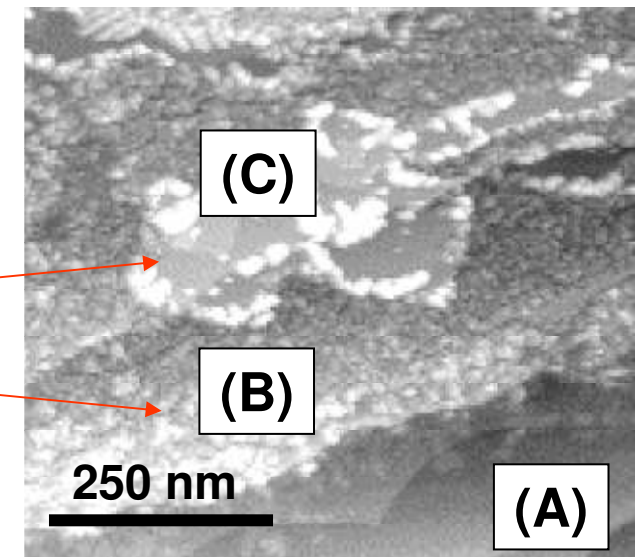
($T = 400$ K, $D = 3.2 \times 10^5$ a²/s,
 $F = 3$ ML/ms, $\tau = 10^4$ s)

Radke, Kundin, Emmerich, Gemming,
Physica D **238** (2009) 117-125.

PTCDA on
KBr|Ag

layer

islands



($f_0 = 155.926$ kHz, $k = 40$ N/m,
 $\Delta f = 34$ Hz, $A_0 = 1,7$ nm)

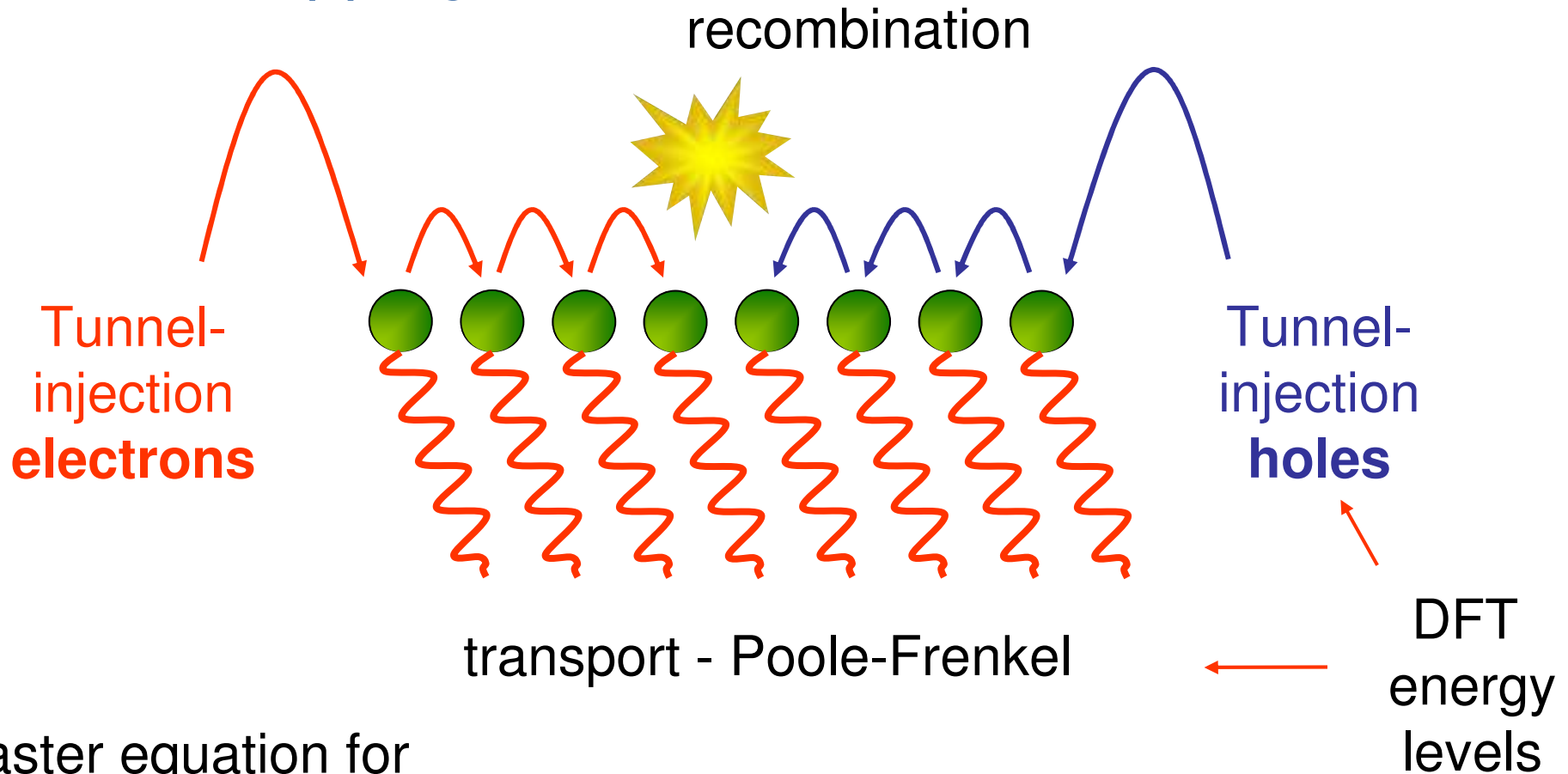
INSTITUTE OF PHYSICS PUBLISHING

Nanotechnology 17 (2006) 1568–1573

Adsorption of PTCDA on a partially KBr covered Ag(111) substrate

Ch Loppacher^{1,4}, U Zerweck¹, L M Eng¹, S Gemming², G Seifert²,
C Olbrich³, K Morawetz³ and M Schreiber³

Classical hopping

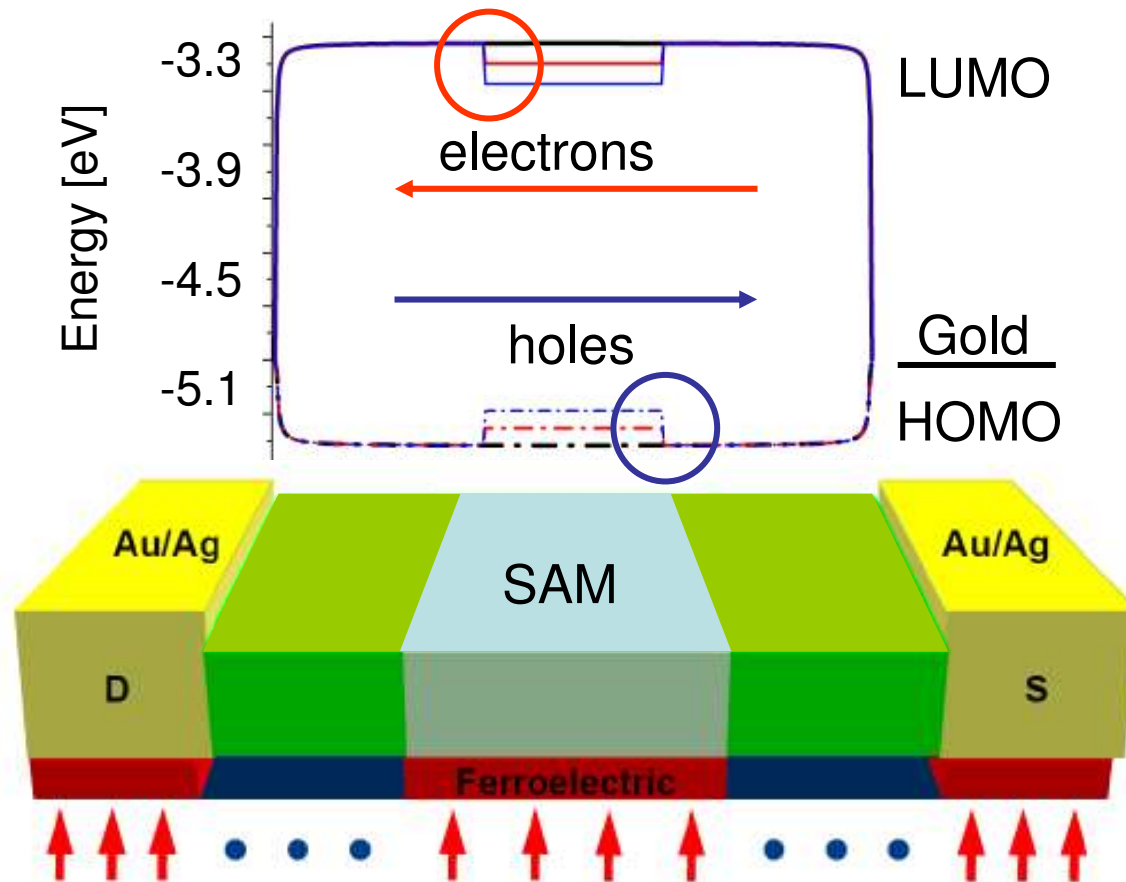


Master equation for carrier densities at each site i

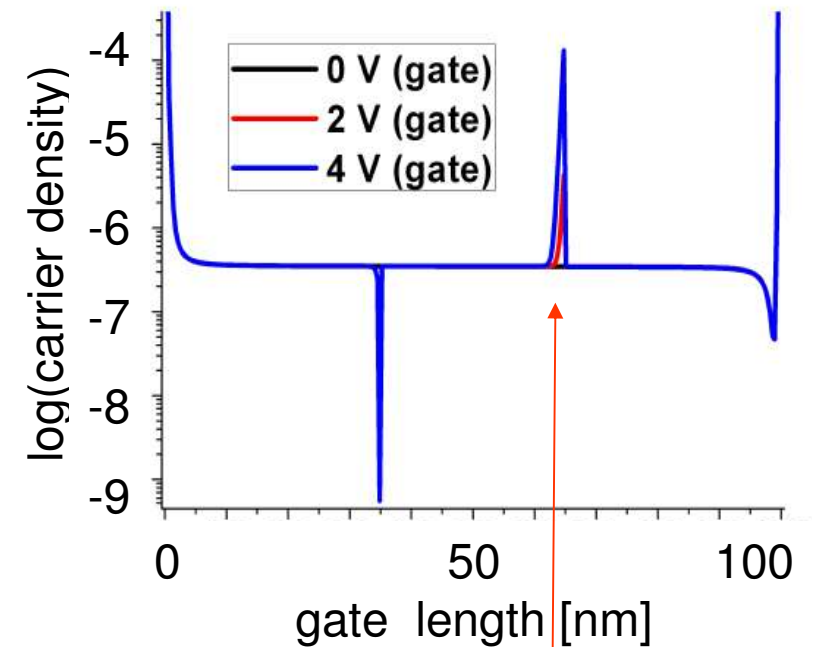
$$n_{\text{new}}^i = n_{\text{old}}^i + \Delta n_{\text{trans}}^i + \Delta n_{\text{tunn}}^i - \Delta n_{\text{rec}}^i$$

Hopping transport

Ferroelectric domain: ΔE



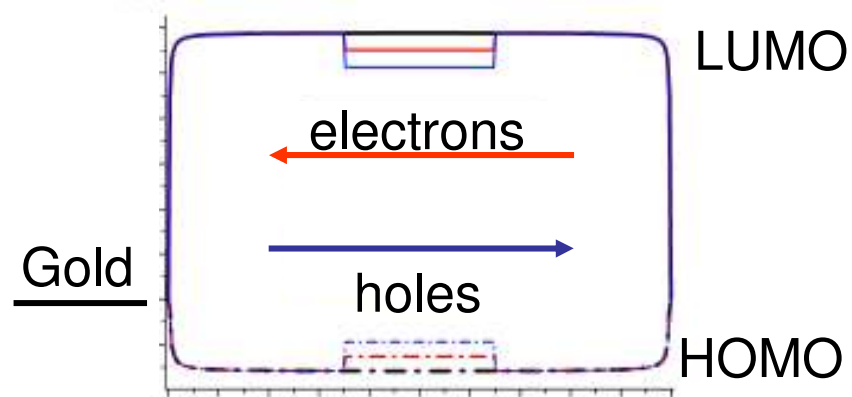
Majority carrier: holes



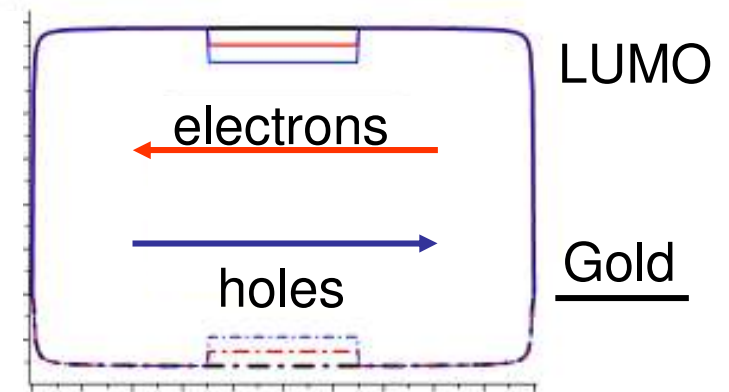
accumulation
increased mobility

Hopping transport - Modifications

Contact metal

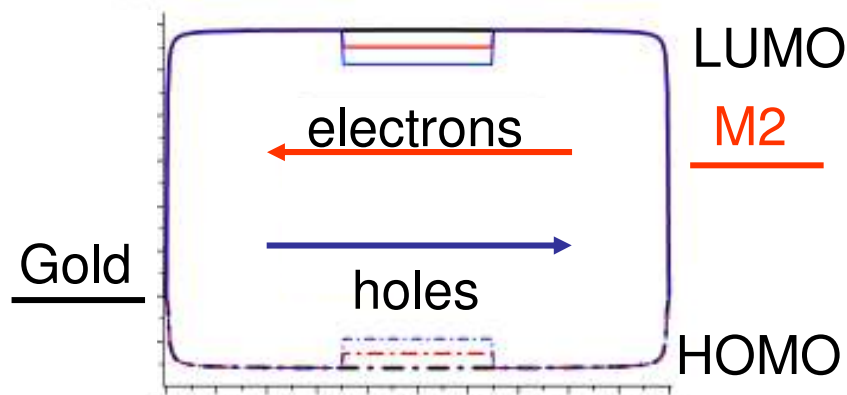


Anchoring group

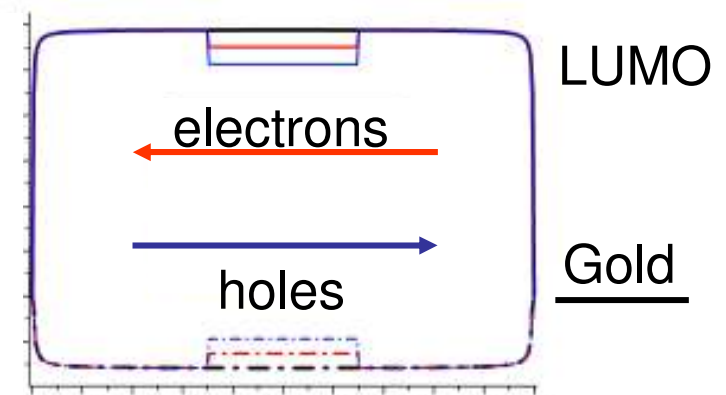


Hopping transport - Modifications

Contact metal



Anchoring group



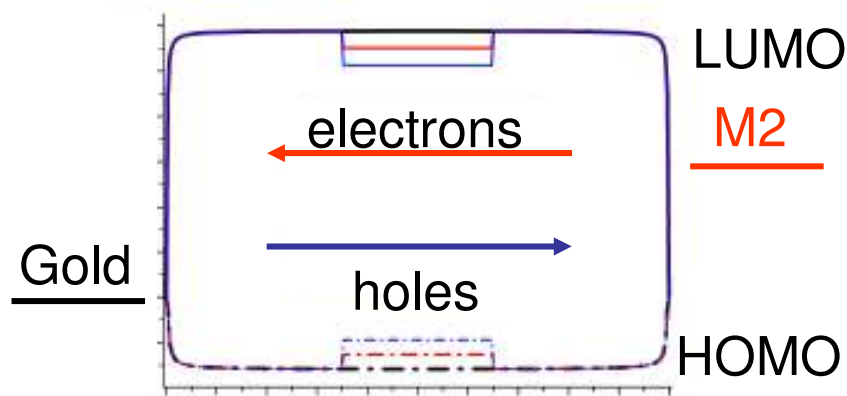
two-level transport
diode effect

Nikolai B Zhitenev^{1,3}, Artur Erbe^{1,4}, Zhenan Bao^{1,5},
Weirong Jiang^{1,2} and Eric Garfunkel²

Nanotechnology **16** (2005) 495–500

Hopping transport - Modifications

Contact metal

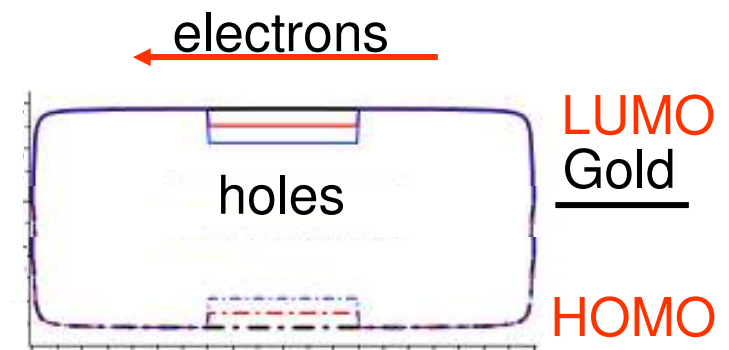


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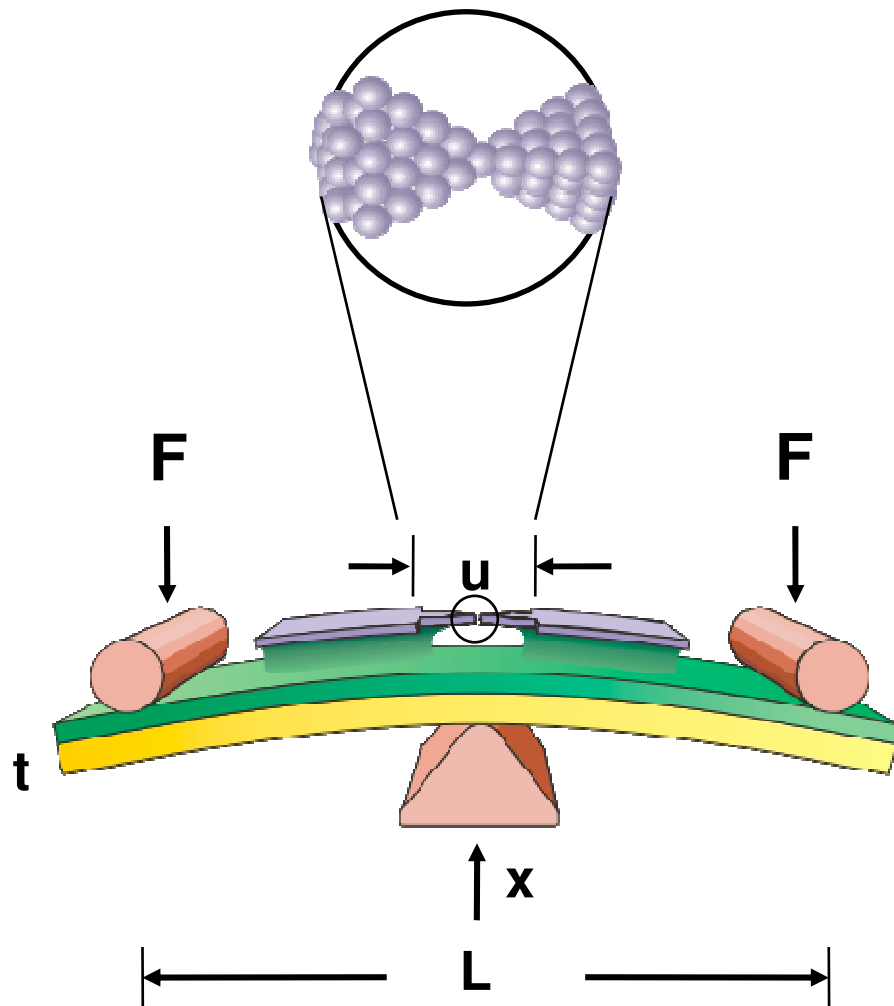


single-level transport
HOMO: SH, LUMO: CN
majority carrier h^+ / e^-

A. Erbe et al.

small 2010, 6, No. 14, 1529–1535

Mechanically controlled break junctions

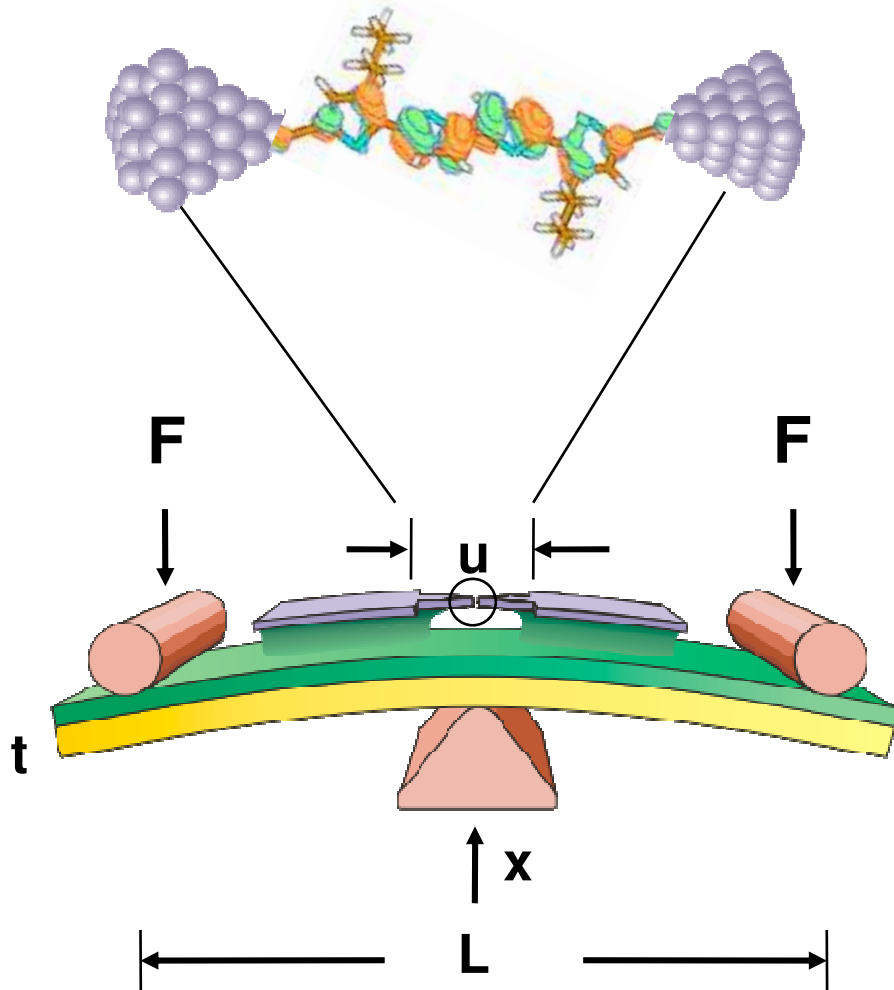


bending by δx



lateral stretching: $\delta u = r \delta x$
 ($r \sim 10^4 - 10^5$)
 = atomic resolution
 with “simple” mechanics

Mechanically controlled break junctions



bending by δx

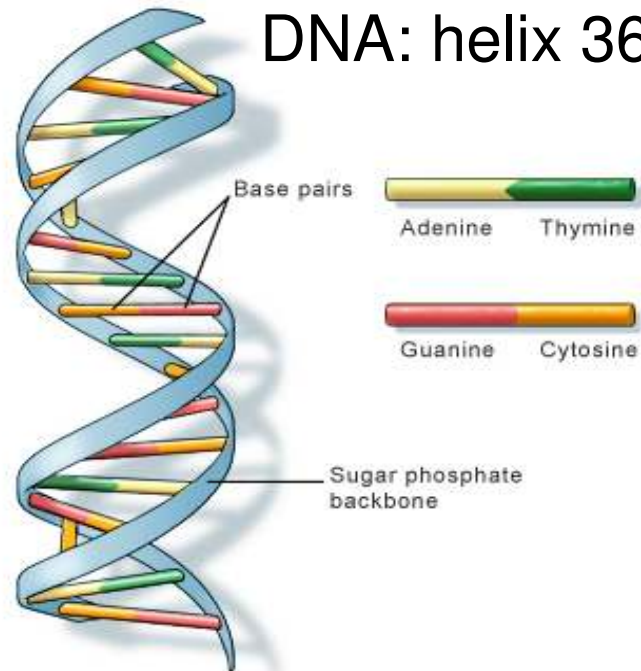


lateral stretching: $\delta u = r \delta x$
($r \sim 10^4 - 10^5$)
= atomic resolution
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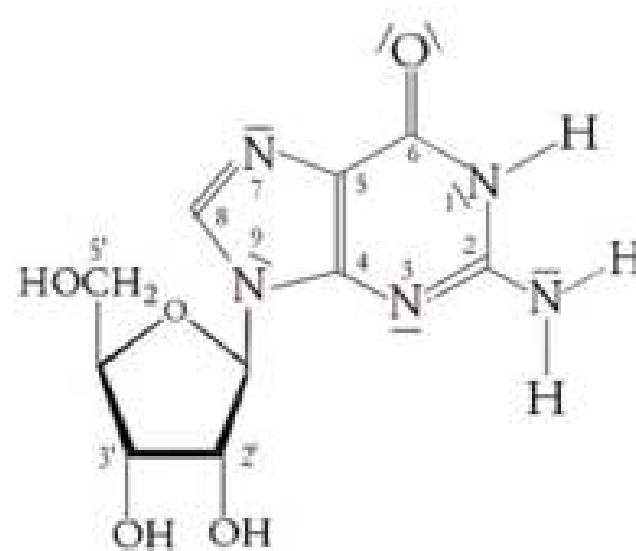
insert molecule
& measure transport

Transport through DNA quadruplexes



S. National Library of Medicine

nucleosides:
G = guanosine



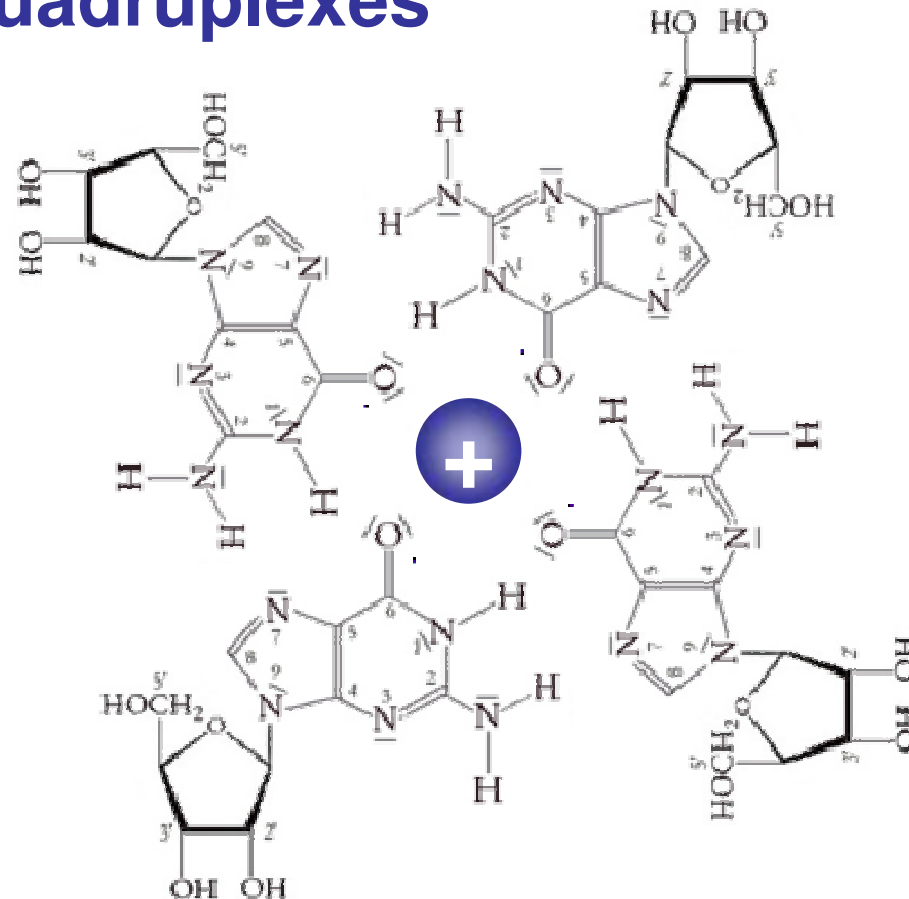
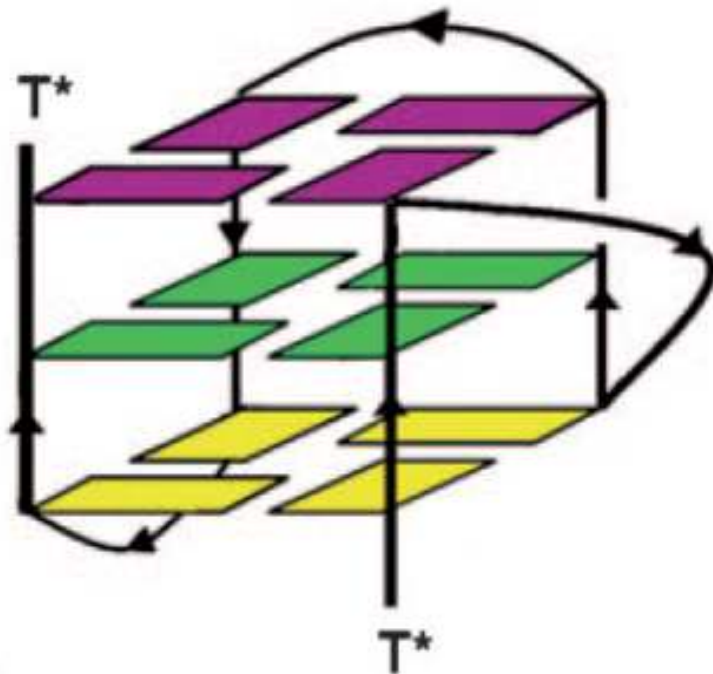
Angewandte
International Edition **Chemie**

Direct Measurement of Electrical Transport Through G-Quadruplex DNA with Mechanically Controllable Break Junction Electrodes**

*Shou-Peng Liu, Samuel H. Weisbrod, Zhuo Tang, Andreas Marx, Elke Scheer, and Artur Erbe**

Transport through DNA quadruplexes

G quadruplex



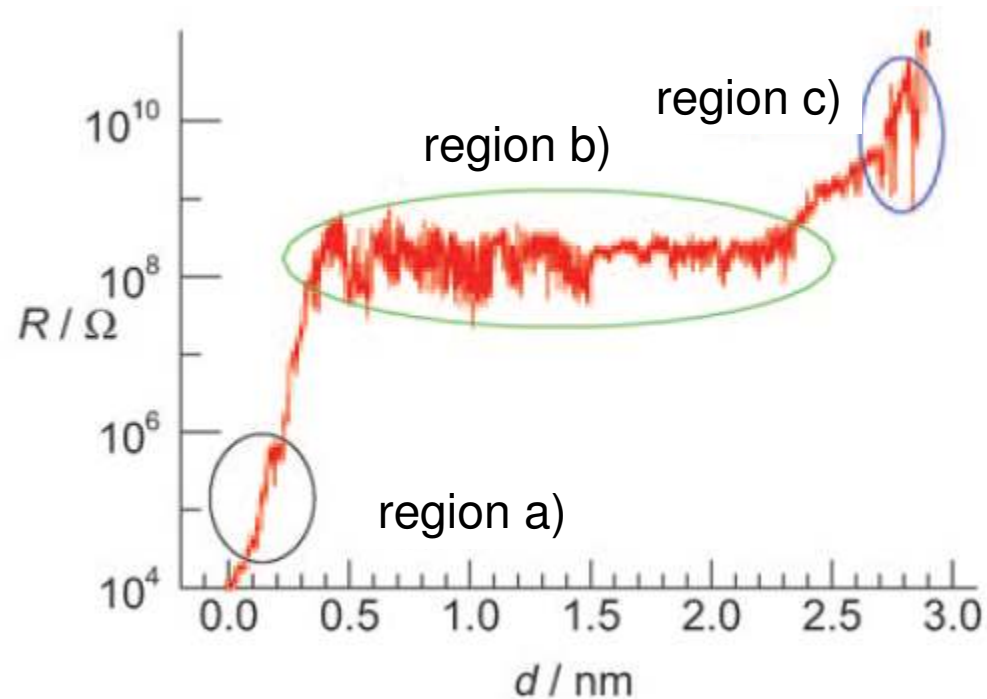
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Transport through DNA quadruplexes

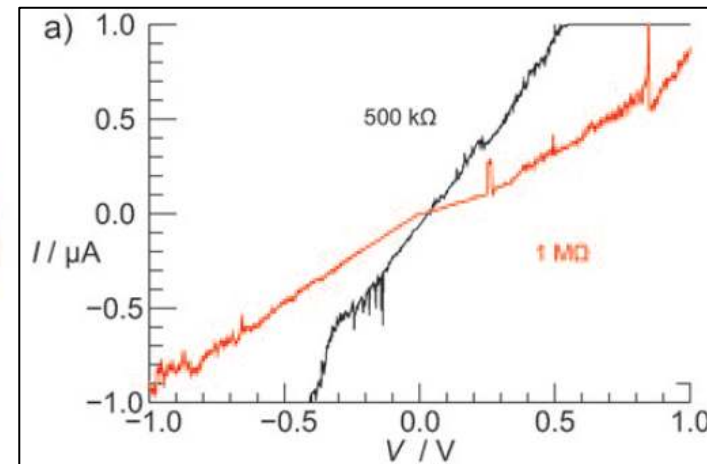
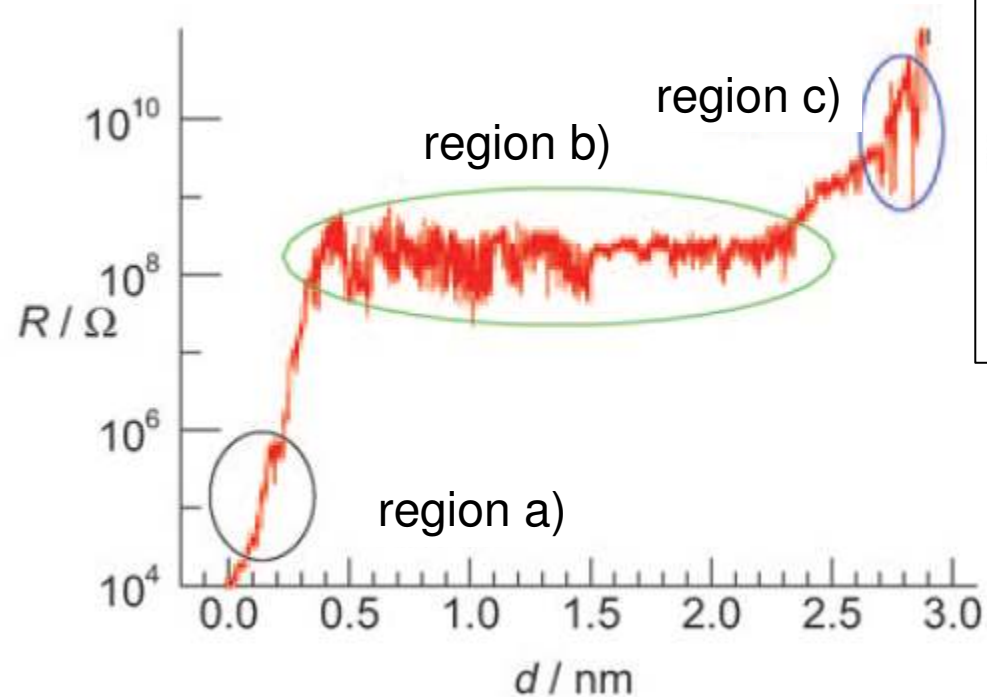
Resistance-distance dependence



Three stage behaviour?

Transport through DNA quadruplexes

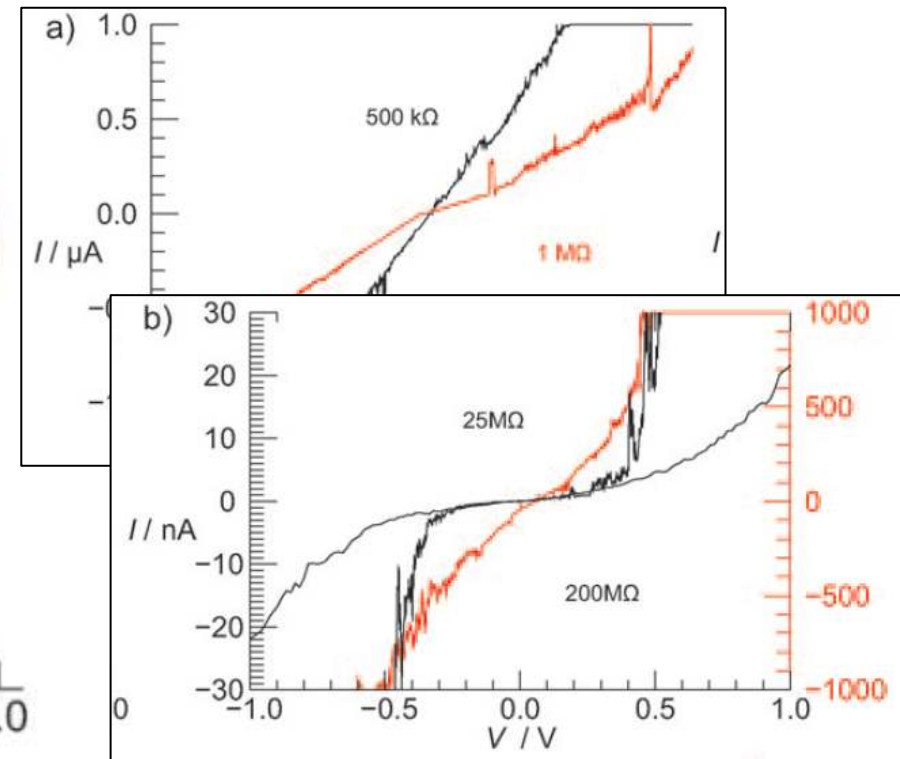
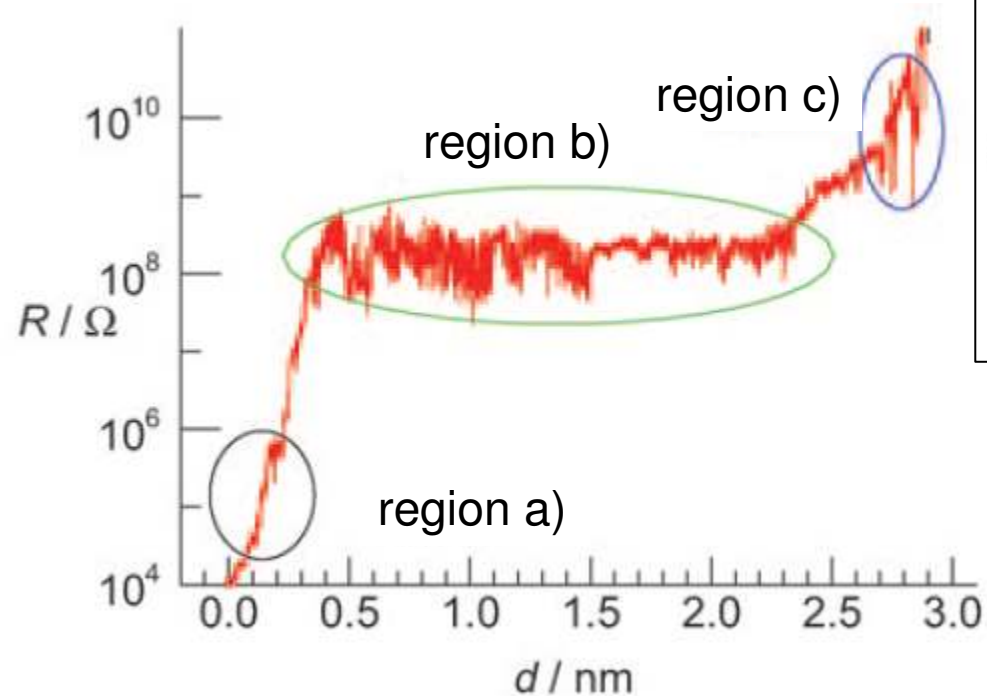
Resistance-distance dependence



a) direct tunneling electrode-electrode

Transport through DNA quadruplexes

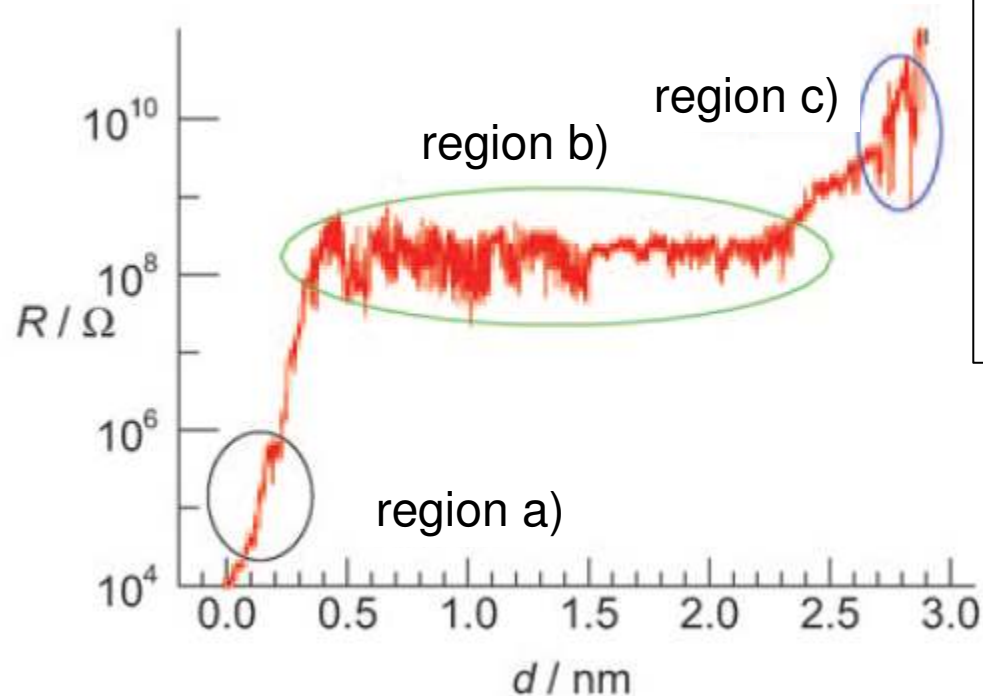
Resistance-distance dependence



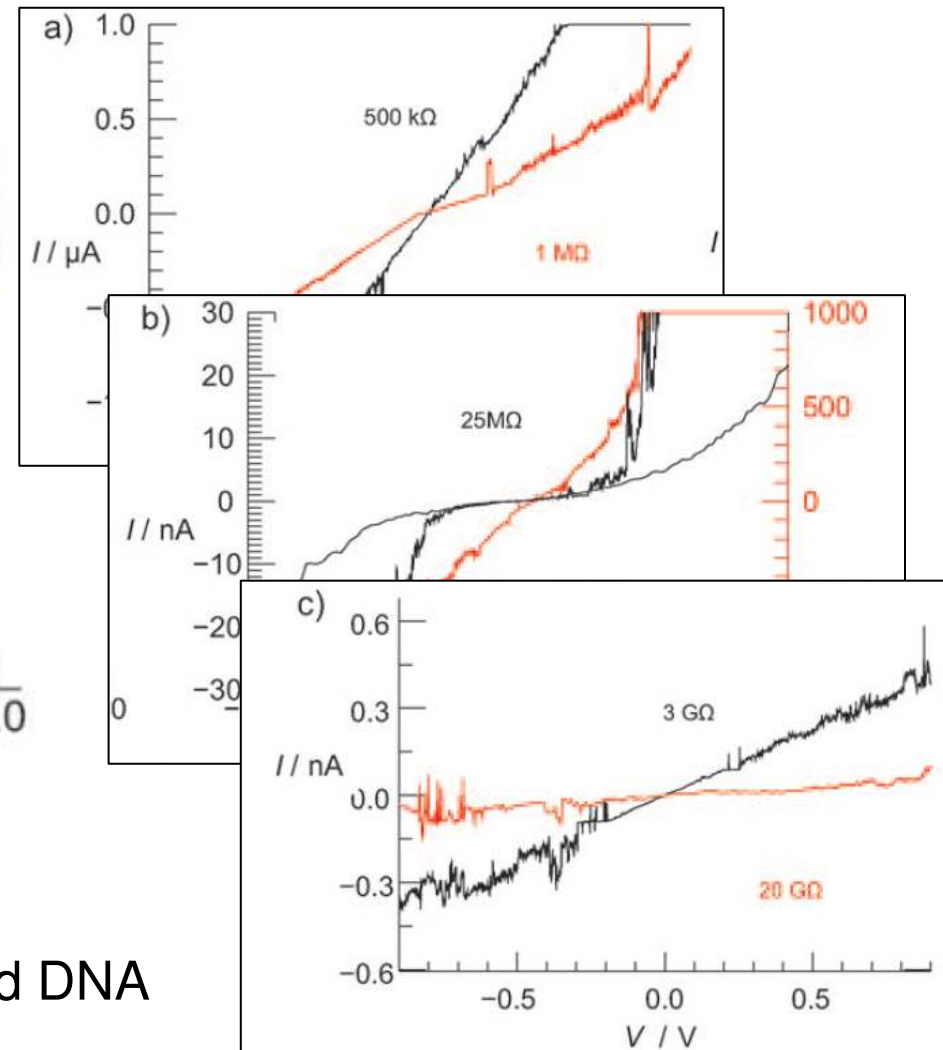
- a) direct tunneling electrode-electrode
- b) quadruplex unfolding

Transport through DNA quadruplexes

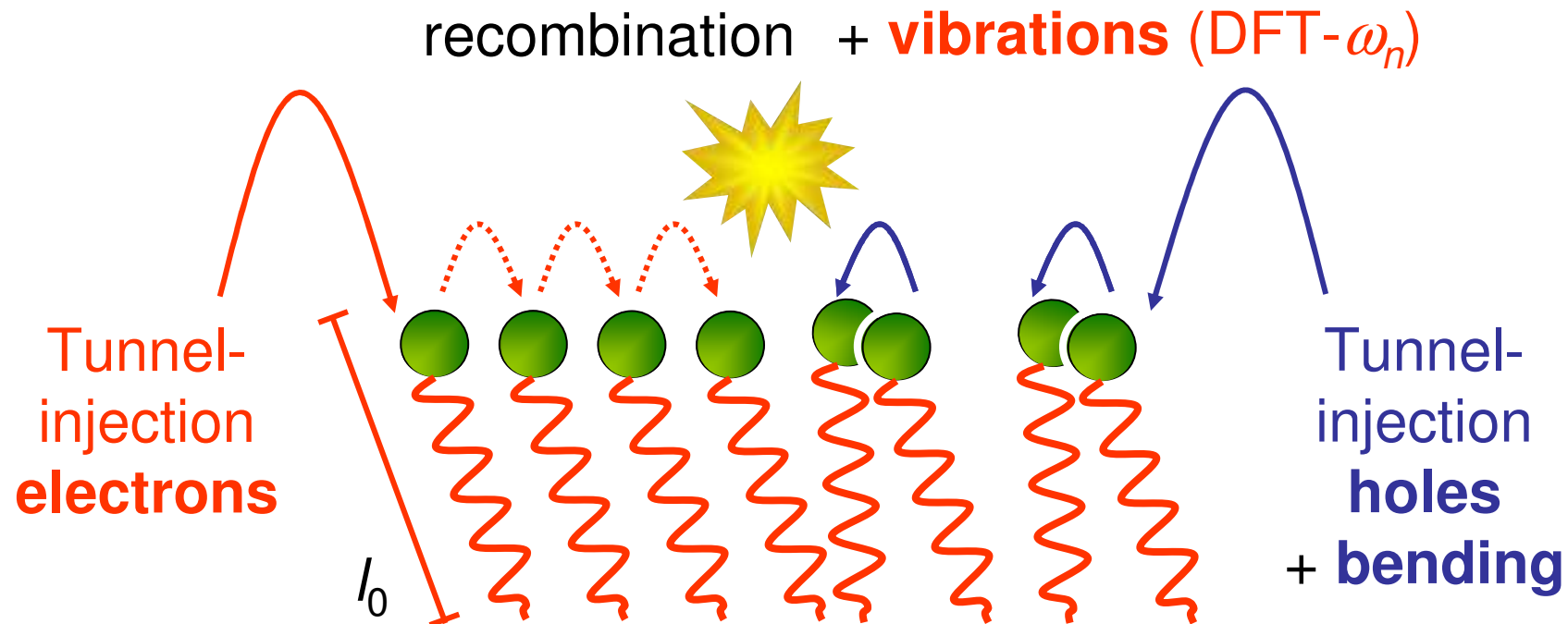
Resistance-distance dependence



- a) direct tunneling electrode-electrode
- b) quadruplex unfolding
- c) tunnel transport through single-strand DNA



Shuttling transport



continuum
elasticity

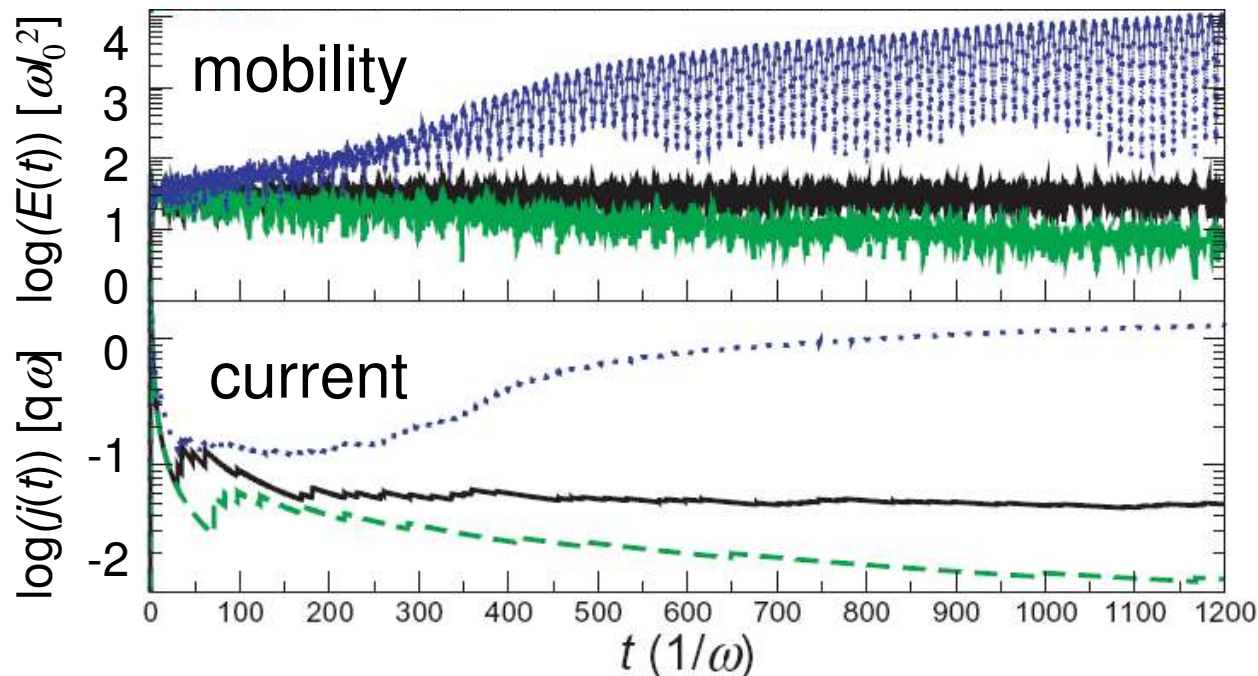
$$x_i(t) = \sum_n \phi_{ni} [(c_n \cos \omega_n t + d_n \sin \omega_n t) + \int_0^t dt' ((\sin \omega_n(t-t')/\omega_n) \sum_m a_m(t') \phi_{nm})]$$

transport equation

$$q_{i,nee} = q_{i,old} + \Delta q_{i,trans} + \Delta q_{i,tunn} - \Delta q_{i,rec}$$

(normal basis: ϕ_{ni})

Shuttling transport – diode effect



bias voltage

-0.2 V = $\uparrow\downarrow$ bending
no current

0.0 V = little current

0.2 V = $\uparrow\uparrow$ bending
high current

New Journal of Physics

The open-access journal for physics

Current without external bias and diode effect
in shuttling transport of nanoshafths

K Morawetz^{1,2,3}, S Gemming¹, R Luschtinetz⁴, L M Eng⁵,
G Seifert⁴ and A Kenfack²

current without bias
diode effect

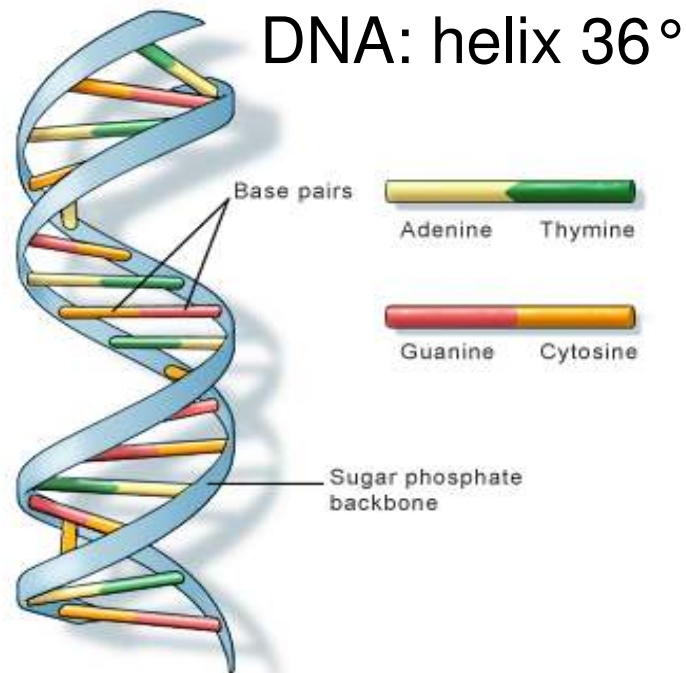
dissipative effects
assist or counteract

Continuous wire/tube gate

CNT@DNA

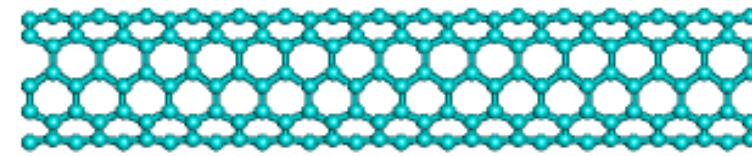
$(\text{Mo}_6\text{S}_6)_\infty$

CNT@DNA as Gate?

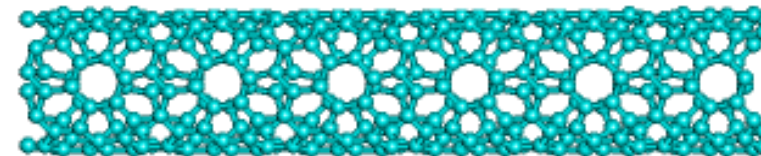


S. National Library of Medicine

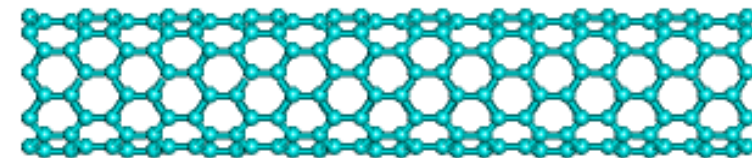
CNT – Winkel ~ Chiralität



armchair (5,5) CNT



chiral (8,2) CNT



zigzag (9,0) CNT

IOP PUBLISHING

NANOTECHNOLOGY

Nanotechnology 18 (2007) 245702 (10pp)

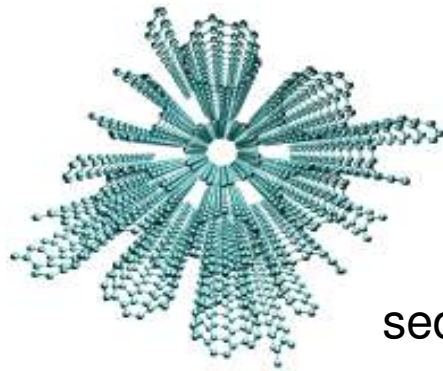
[doi:10.1088/0957-4484/18/24/245702](https://doi.org/10.1088/0957-4484/18/24/245702)

DNA-wrapped carbon nanotubes

A N Enyashin^{1,2}, S Gemming³ and G Seifert¹

Formation energy of CNT@DNA aggregates

E_{coh} – cohesion of CNT bundles

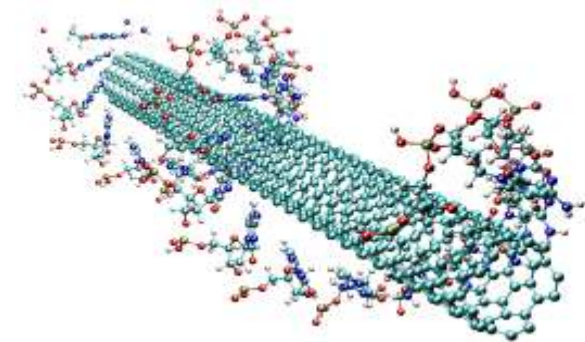


CNT sediment



single CNT

E_{ads} – adsorption
DNA – base
on CNT



CNT@DNA complex

E_{def} – Deformation des DNA Strangs



ss-DNA molecule



distorted ss-DNA

ΔE_f – formation
energy

Classical interaction model

first-principles
(DFT, HF-MP2)

$$E_{\text{coh}}, E_{\text{def}}, E_{\text{int}}$$



$$\Delta E_f = E_{\text{coh}} + NE_{\text{def}} + N_{\text{base}}E_{\text{int}}$$

analytic form

(N_{base} : number of
bases)

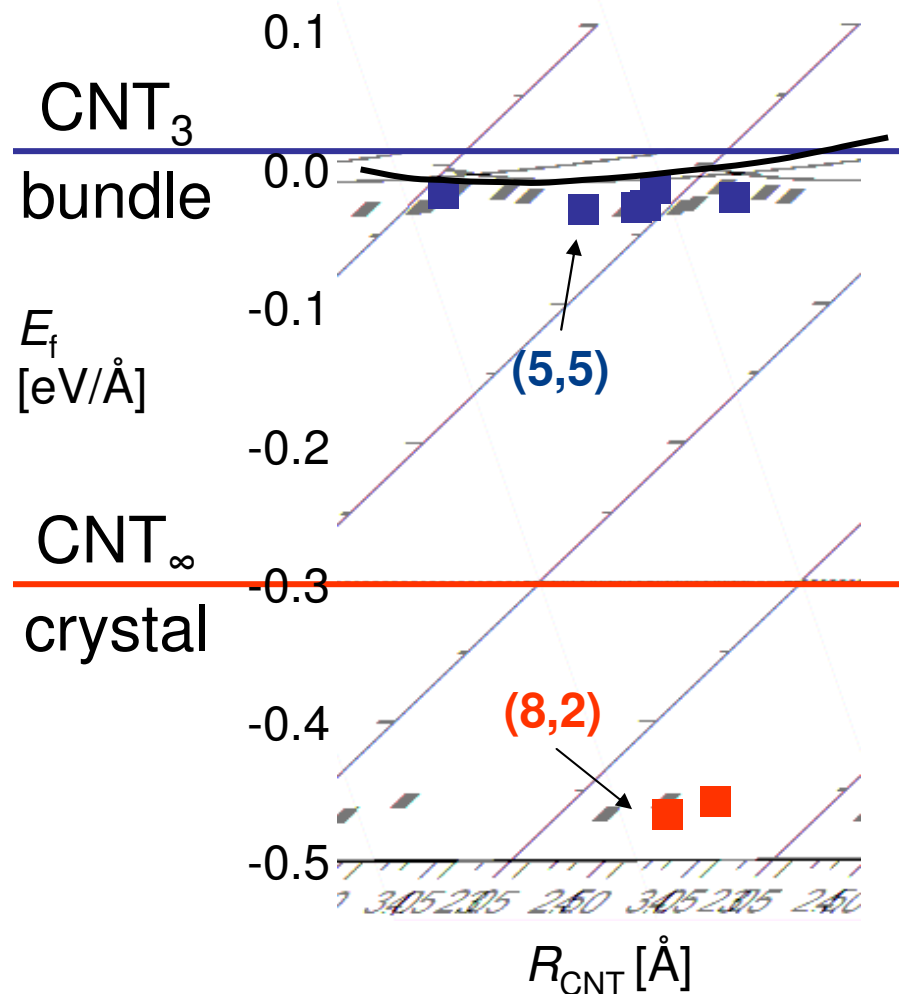
$$E_{\text{coh}} = a\sqrt{R_{\text{CNT}}}$$

$$E_{\text{def}} = a + b/(R_{\text{DNA}})^3 + cR_{\text{DNA}} + dR_{\text{DNA}}^2$$

$$R_{\text{DNA}} = R_{\text{CNT}} + l_{\text{vdW}} + l_{\text{C-N}}$$

(R : radius, N : number of DNA strands)

Validation vs. quantum mechanics: DFTB/disp



classical
DFTB

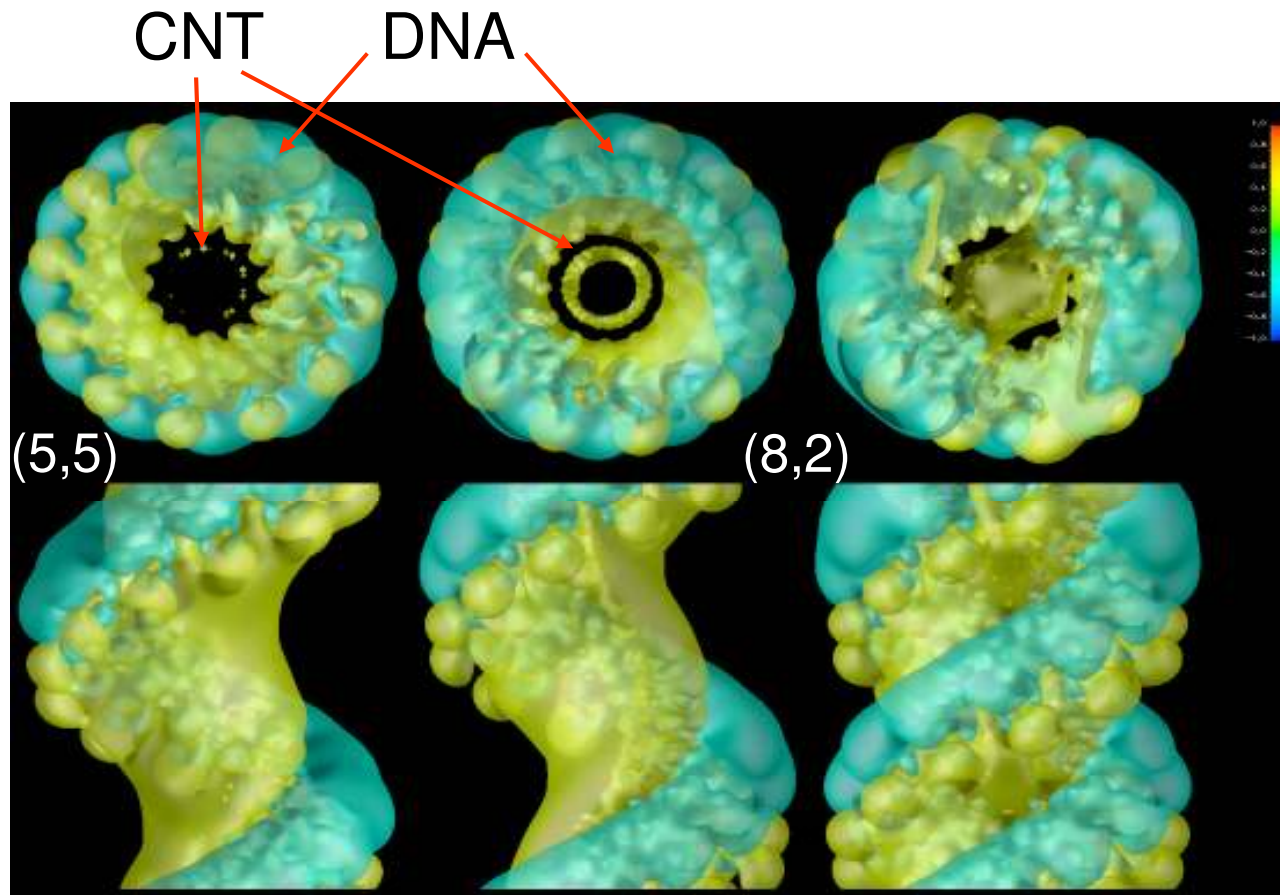
most cases
classical = QM

preferably
from CNT bundles
(sonicate!)

DFTB

metallic & chiral CNT
stronger interaction

DF-TB – Charge transfer in CNT@DNA



electrostatic field: $+0.4 \text{ e}/\text{\AA}$ (y) and $-0.4 \text{ e}/\text{\AA}$ (b)

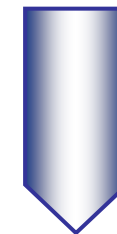
electron transfer

(5,5) @ poly-C: -0.005

(8,2) @ poly-C: -0.374

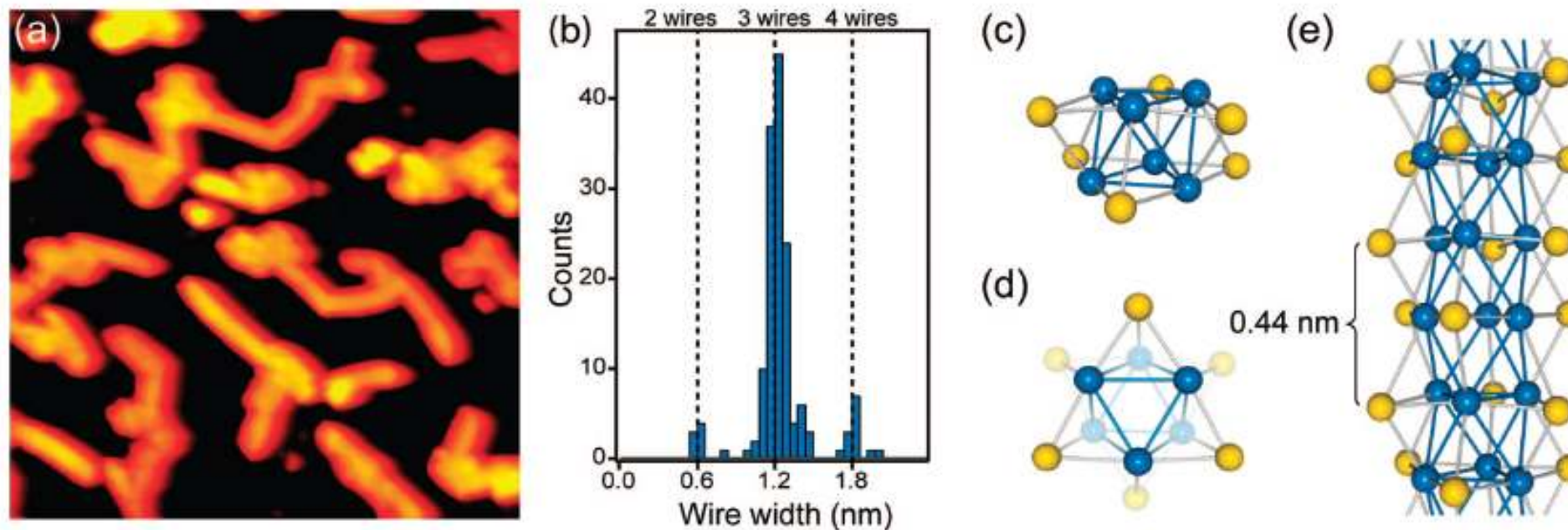
2 poly-C: -0.825

(7,4) @ poly-C: -0.237



polar,
resonant transfer
ballistic transport

MoS₂ – based nanowires: S-deficient Mo₆S₆



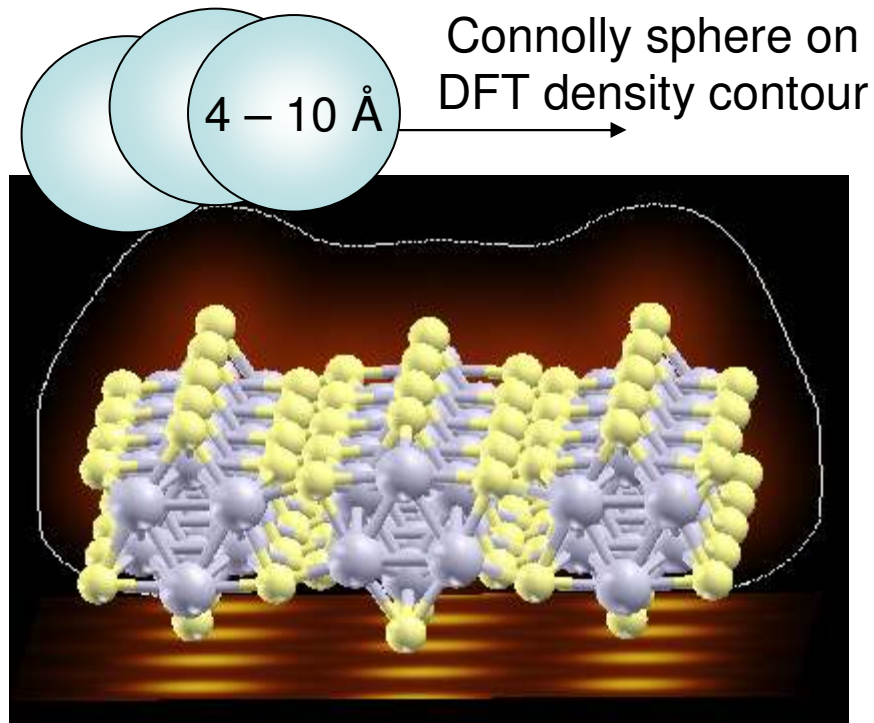
Atomic-Scale Structure of Mo₆S₆ Nanowires



Jakob Kibsgaard,[†] Anders Tuxen,[†] Martin Levisen,[†] Erik Lægsgaard,[†]
 Sibylle Gemming,[‡] Gotthard Seifert,[§] Jeppe V. Lauritsen,^{*,†}
 and Flemming Besenbacher^{*,†}

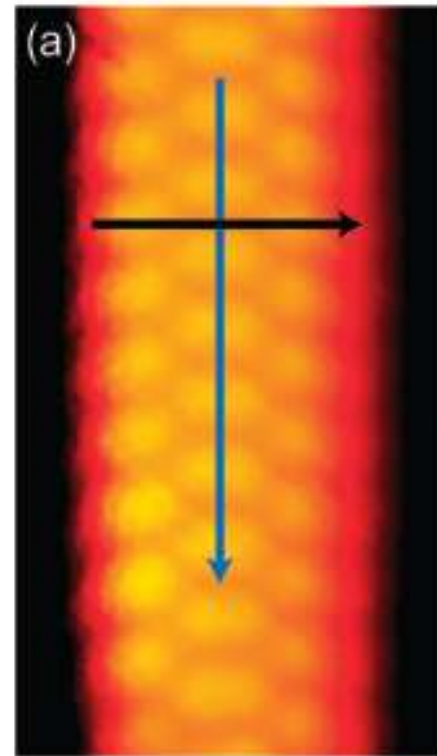
(*Nano Lett.* **8** (2008) 3928-3931)

Mo₆S₆ nanowires: STM - structure

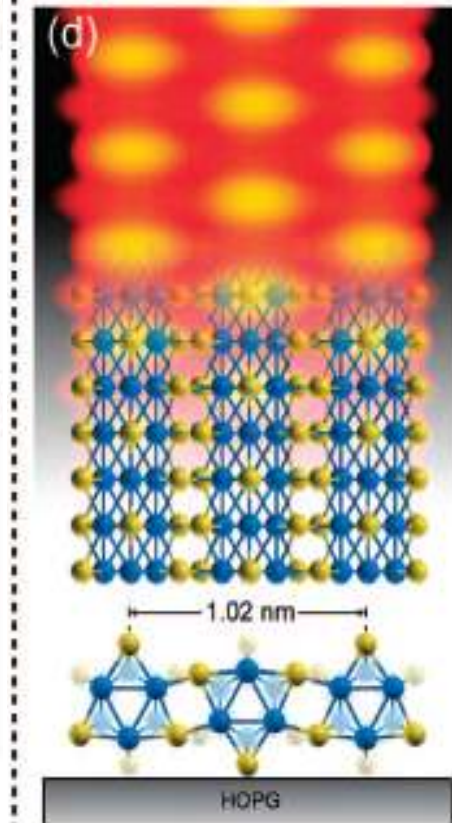


maxima at S
distances 4.4 Å, 10.2 Å
wire height 9.4(±0.1)Å

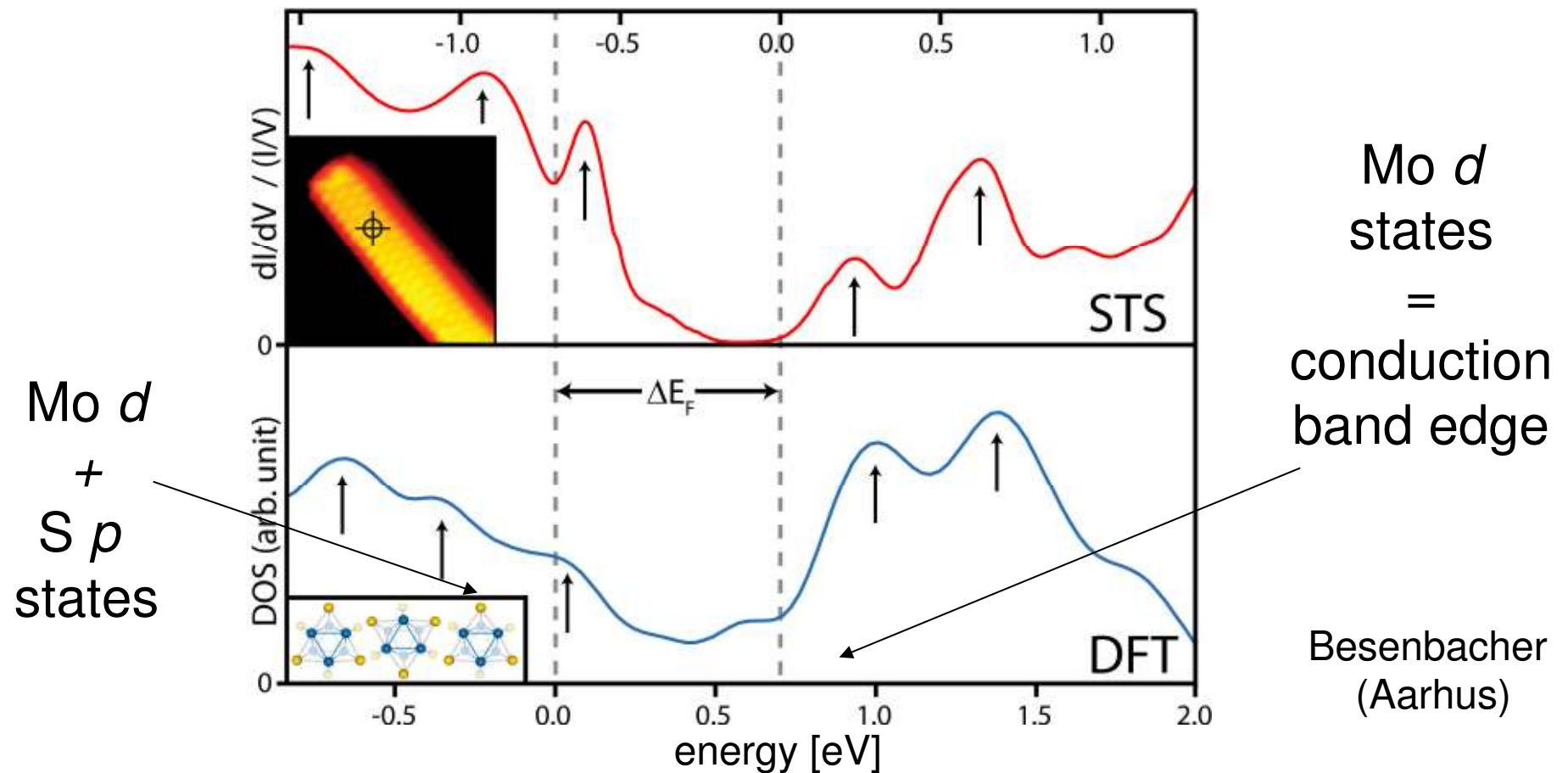
experiment



simulation

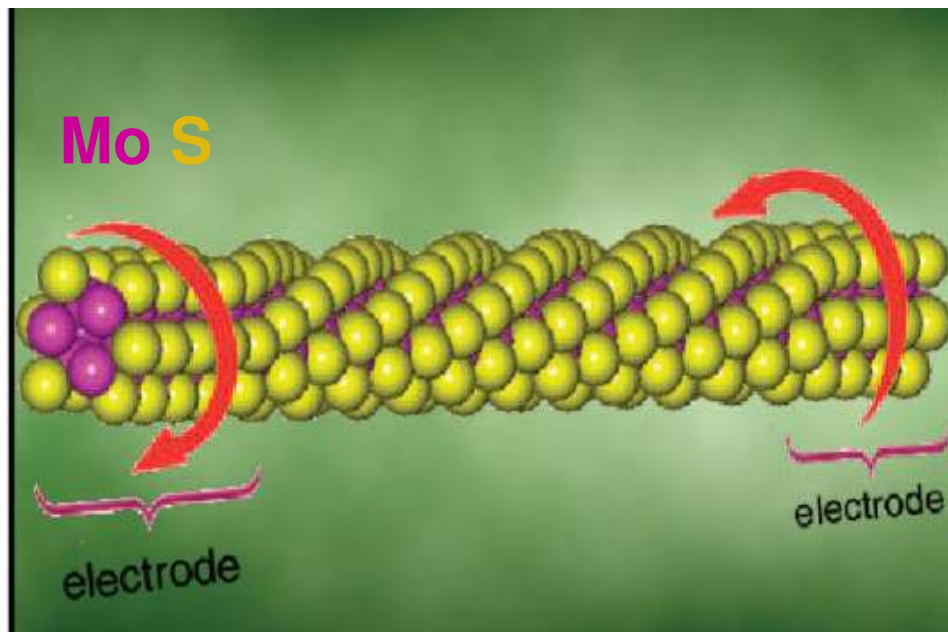


Mo₆S₆ nanowires: STS - conductivity

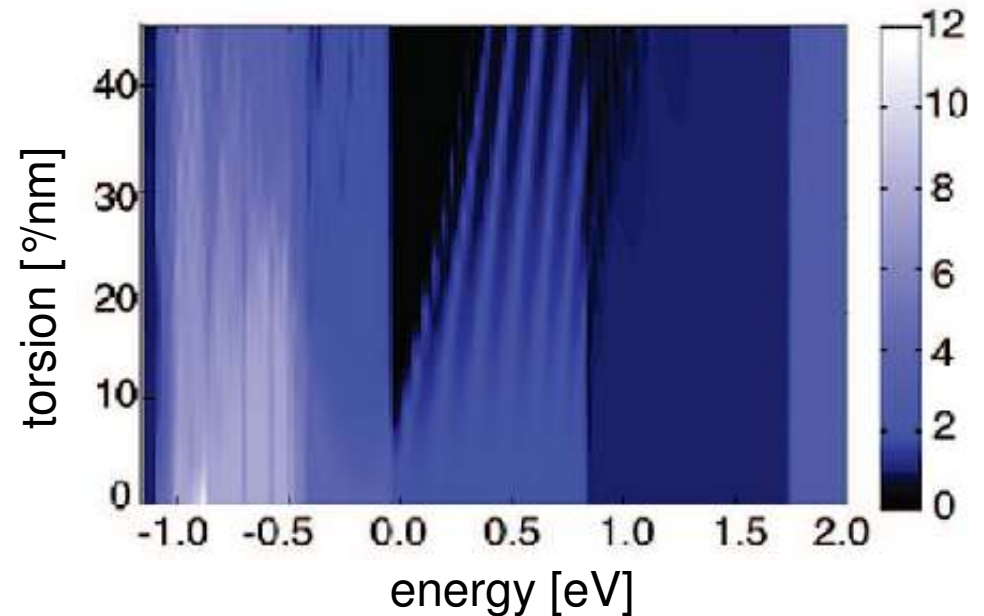


metallic conductance through Mo part, S insulates

Mo₆S₆ : Electromechanic switch



DFPT: Transmission



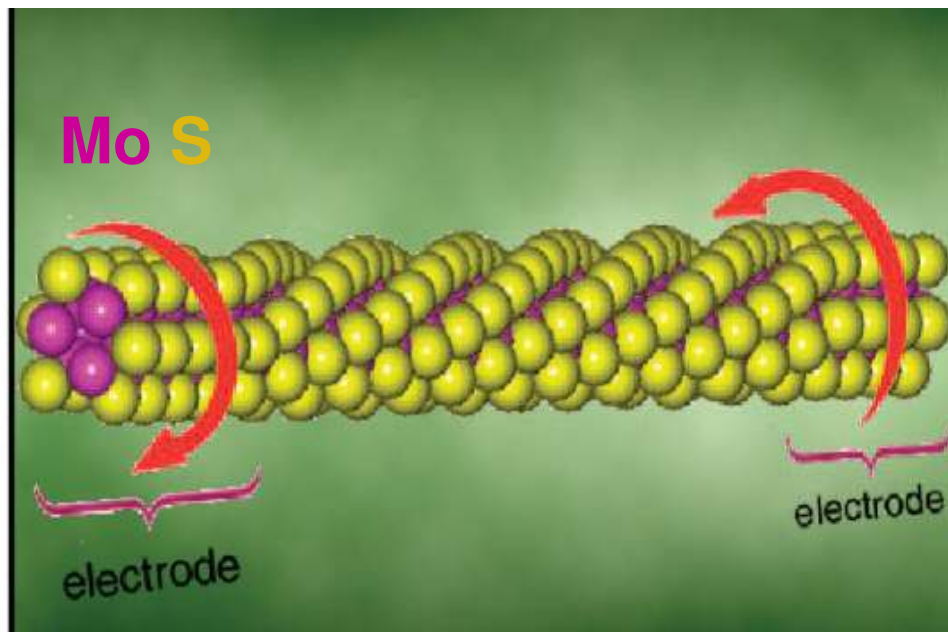
Electromechanical Switch Based on Mo₆S₆ Nanowires

Igor Popov,^{*,†} Sibylle Gemming,[‡] Shinya Okano,[†] Nitesh Ranjan,[§]
and Gotthard Seifert[†]

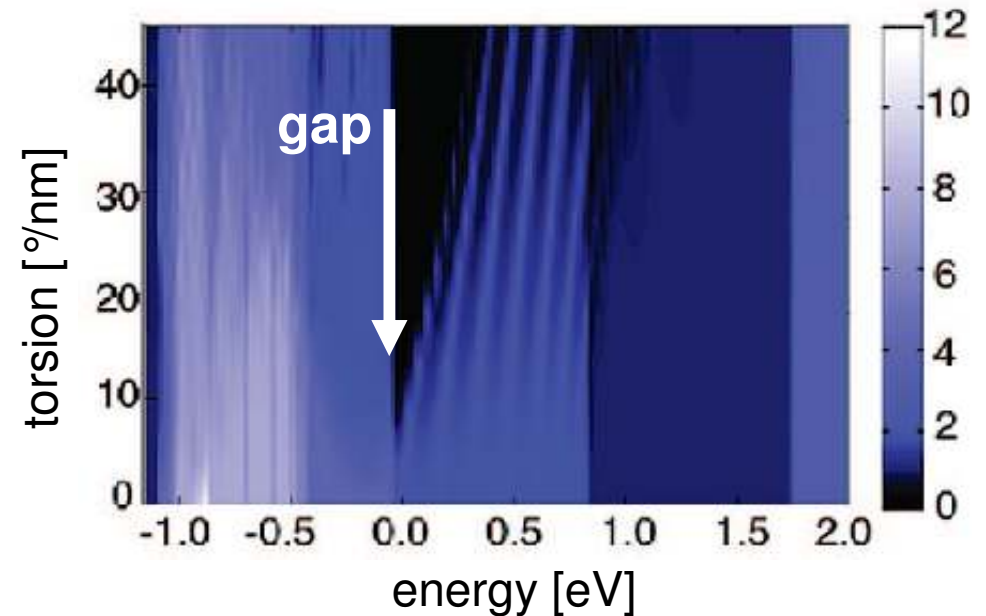
**NANO
LETTERS**

(*Nano Lett.* **8** (2008) 4093-4097)

Mo₆S₆ : Electromechanic switch



DFPT: Transmission



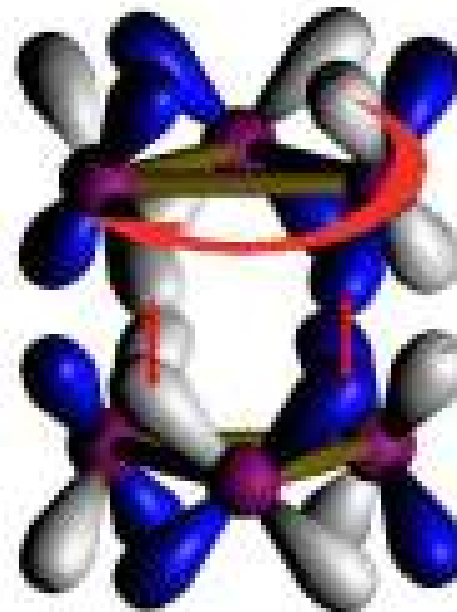
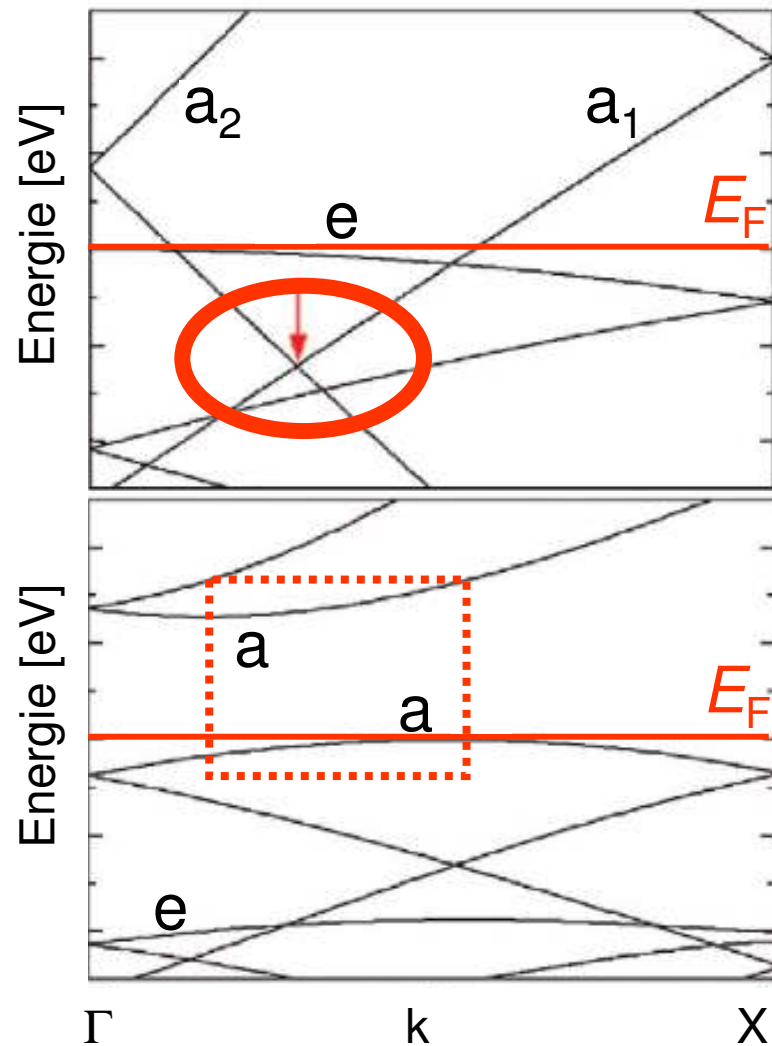
Electromechanical Switch Based on Mo₆S₆ Nanowires

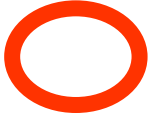
Igor Popov,^{*,†} Sibylle Gemming,[‡] Shinya Okano,[†] Nitesh Ranjan,[§]
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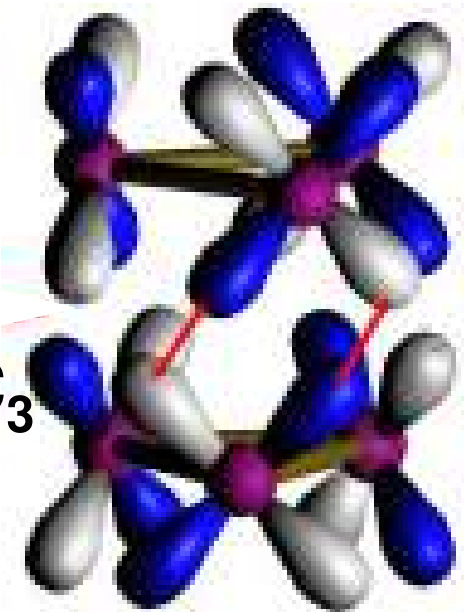
**NANO
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(*Nano Lett.* **8** (2008) 4093-4097)

Mo₆S₆ : Structure-induced metal-insulator transition!



ideal: C_{3v}
 allowed 
 a_1 - a_2 -crossing



distorted: C_3
 forbidden 
 a - a -crossing

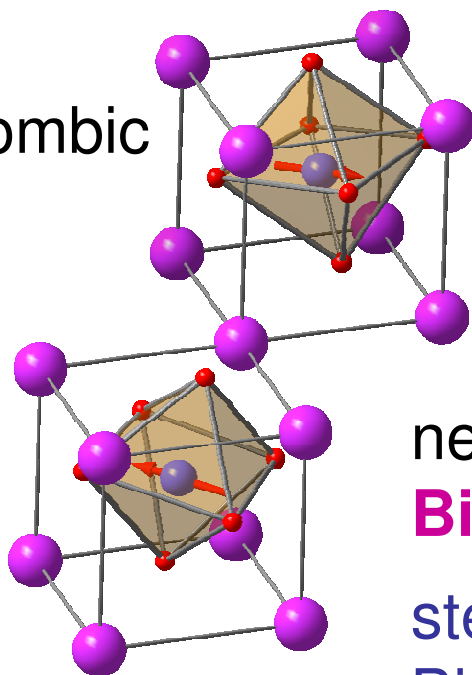
Switching – Electrostatic field on interfaces

Domain walls in BiFeO_3

Electrostatic field at domain boundaries

BiFeO₃

orthorhombic
unit cell



tilted
FeO₆
octahedra

near-cubic
Bi arrangement
stereoactive
Bi lone pair

nature
materials

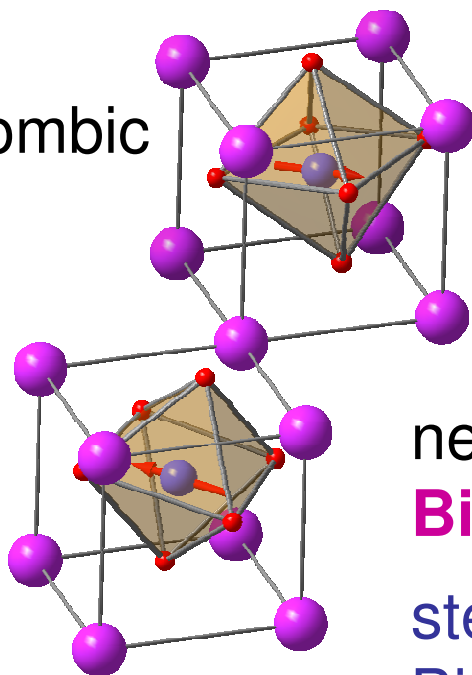
Conduction at domain walls in oxide multiferroics

J. Seidel^{1,2*}†, L. W. Martin^{2,3*}, Q. He¹, Q. Zhan², Y.-H. Chu^{2,3,4}, A. Rother⁵, M. E. Hawkrige²,
P. Maksymovych⁶, P. Yu¹, M. Gajek¹, N. Balke¹, S. V. Kalinin⁶, S. Gemming⁷, F. Wang¹, G. Catalan⁸,
J. F. Scott⁸, N. A. Spaldin⁹, J. Orenstein^{1,2} and R. Ramesh^{1,2,3}

Electrostatic field at domain boundaries

BiFeO₃

orthorhombic
unit cell



tilted
FeO₆
octahedra

near-cubic
Bi arrangement
stereoactive
Bi lone pair

§ antiferromagnet

$T_N \sim 650 \text{ K}$

§ rhombohedral ferroelectric

$T_C \sim 1103 \text{ K}$

§ spontaneous polarization

$P \sim 90 \text{ C cm}^{-2}$

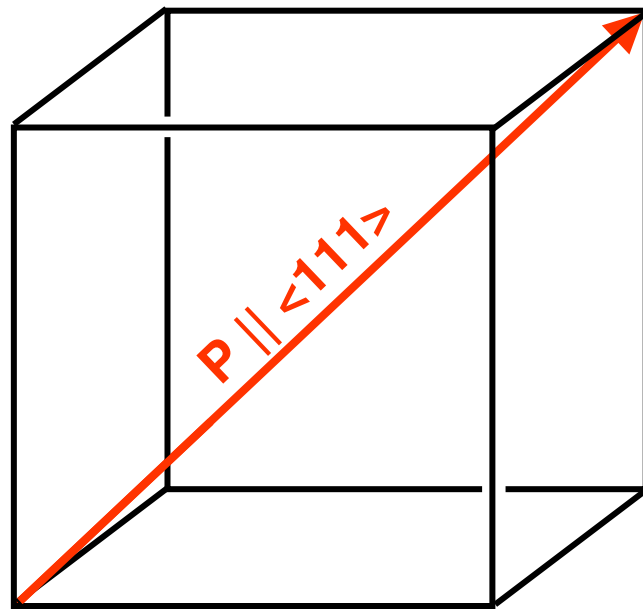
along pseudocubic $\langle 111 \rangle$

nature
materials

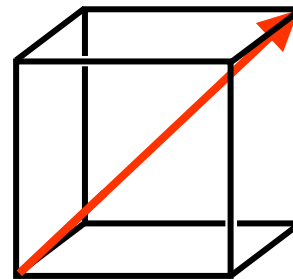
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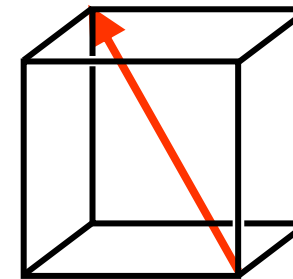
Relative domain orientations



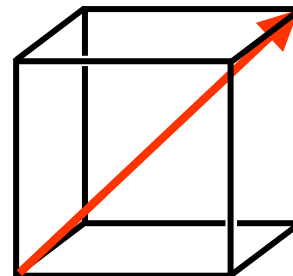
ferroelectric
polarization
 $P \parallel \langle 111 \rangle$



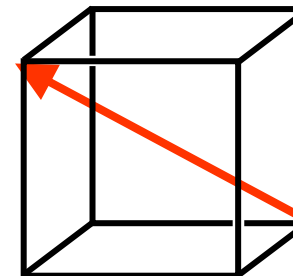
+



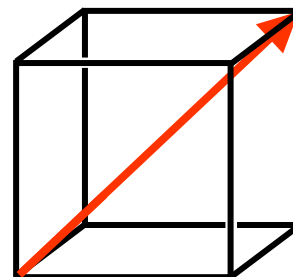
71° wall



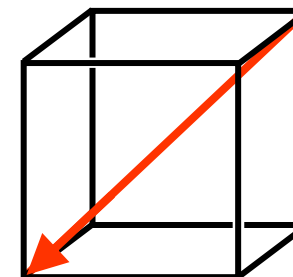
+



109° wall

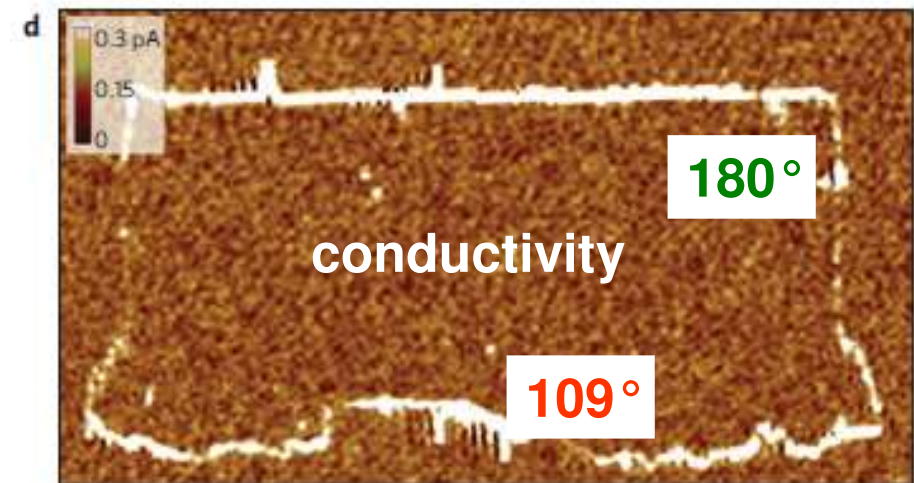
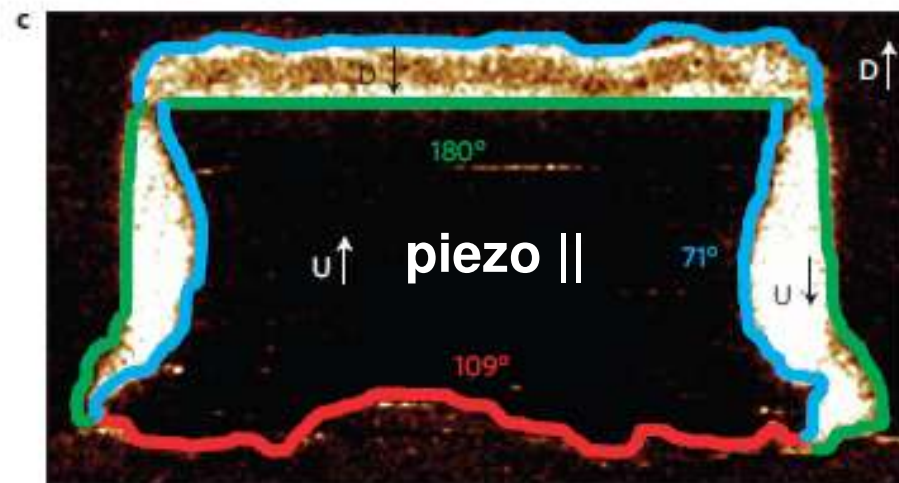
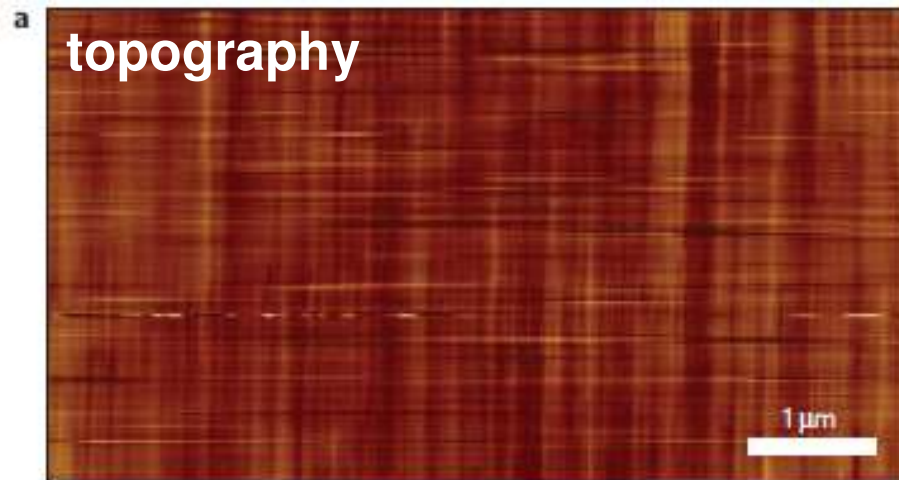


+



180° wall

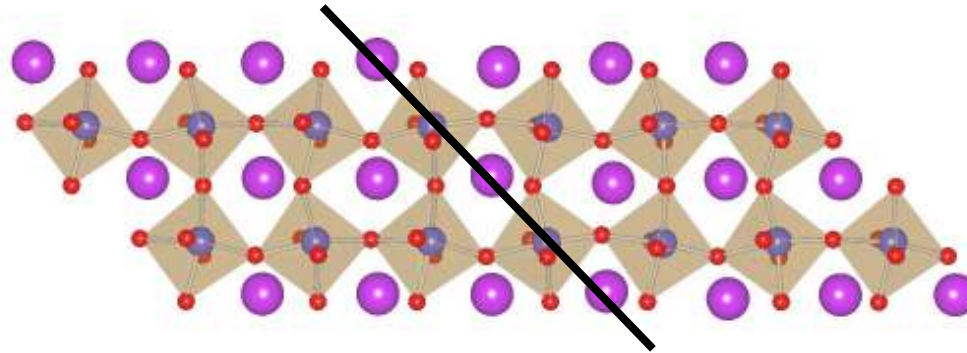
Observed domain walls



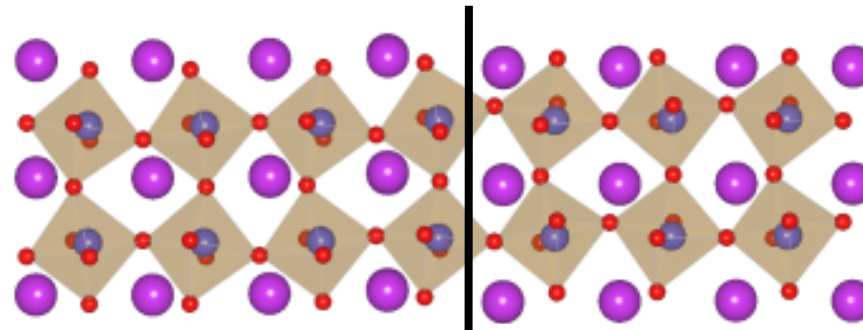
71° 109° 180°

Domain wall structures

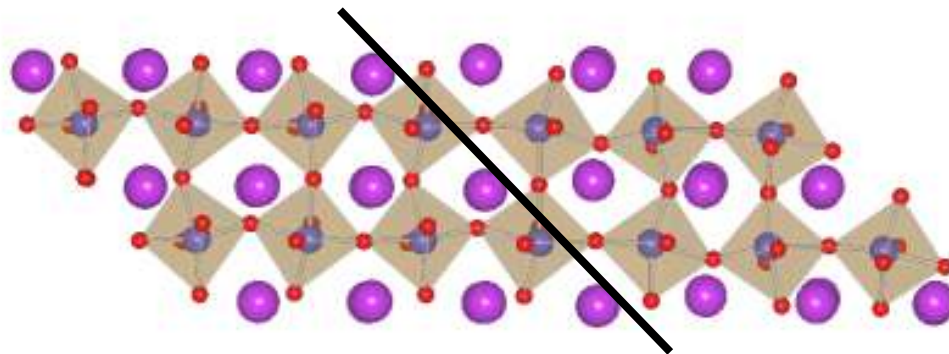
71° wall



109° wall

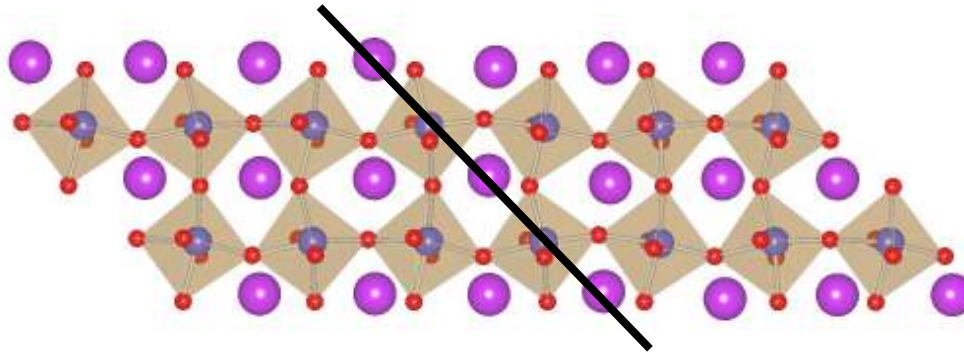


180° wall



Domain wall structures – electronic structure

71° wall



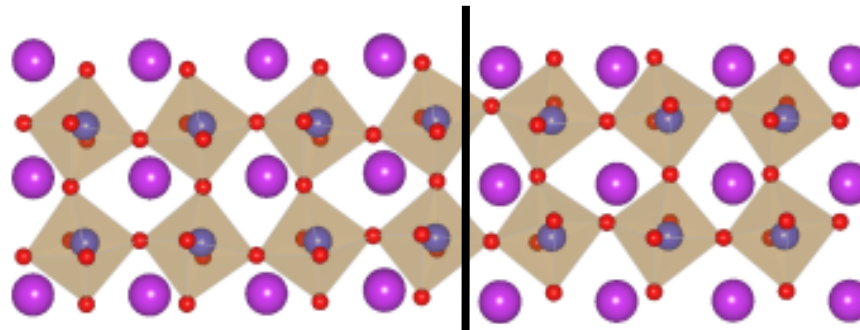
$$E_D = 0.36 \text{ J/m}^2$$

$$\Delta V = 0.02 \text{ eV}$$

$$\Delta E_g = -0.05 \text{ eV}$$

109° wall

very stable
conducting!



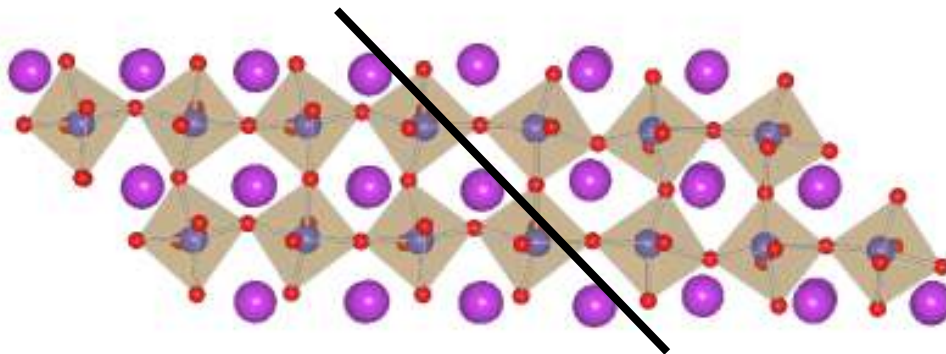
$$E_D = 0.21 \text{ J/m}^2$$

$$\Delta V = 0.18 \text{ eV}$$

$$\Delta E_g = -0.20 \text{ eV}$$

180° wall

conducting!



$$E_D = 1.81 \text{ J/m}^2$$

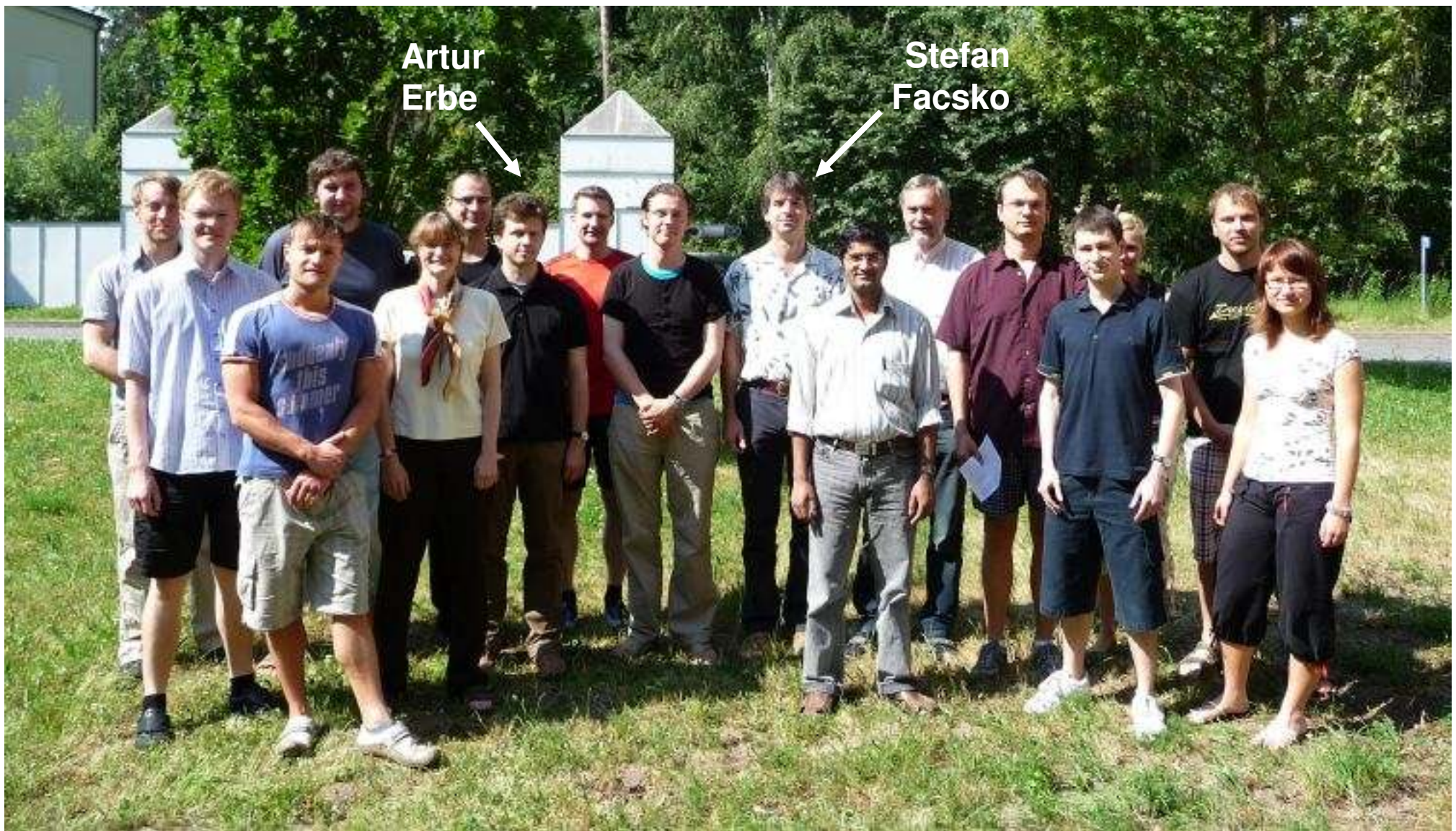
$$\Delta V = 0.15 \text{ eV}$$

$$\Delta E_g = -0.10 \text{ eV}$$

Conclusions

- § Hopping transport
 - § Parameter transfer first-principle to classical transport
 - § Transport without bias by shuttling
- § Ballistic transport
 - § Model derivation from first-principles data
 - § Elastomechanic metal-insulator transition
- § Transport at defects in the bulk
 - § Existence of strong surface/interface polarizations
 - § Origin of conductivity at domain walls





§ Collaborators @ FZD

A. Erbe

T. Kunze

K. Morawetz

V. Pankoke

T. Weißbach

M. Zschornak

A. Lubk (Rother)

C. Olbrich

I. Popov

W. Alsheimer

§ Experiments

R. Ramesh (Berkeley)

F. Besenbacher (Aarhus)

R. Tenne (Weizman)

L.M. Eng (Dresden)

§ Theory

G. Seifert, R. Lushtinetz

A.N. Enyashin (Ekaterinburg)

N. Spaldin (Santa Barbara)

§ Euros

DFG, BMBF, DAAD, GIF

Thank you!



Forschungszentrum
Dresden Rossendorf

